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United States Patent

Kind Code

Bate of Patent

Inventor(s)

12389677

August 12, 2025

Chida; Akihiro

# Light-emitting device and method for manufacturing the same

#### Abstract

A highly reliable light-emitting device and a manufacturing method thereof are provided. A light-emitting element and a terminal electrode are formed over an element formation substrate; a first substrate having an opening is formed over the light-emitting element and the terminal electrode with a bonding layer provided therebetween; an embedded layer is formed in the opening; a transfer substrate is formed over the first substrate and the embedded layer; the element formation substrate is separated; a second substrate is formed under the light-emitting element and the terminal electrode; and the transfer substrate and the embedded layer are removed. In addition, an anisotropic conductive connection layer is formed in the opening, and an electrode is formed over the anisotropic conductive connection layer. The terminal electrode and the electrode are electrically connected to each other through the anisotropic conductive connection layer.

Inventors: Chida; Akihiro (Isehara, JP)

**Applicant:** Semiconductor Energy Laboratory Co., Ltd. (Atsugi, JP)

**Family ID:** 51523630

Assignee: Semiconductor Energy Laboratory Co., Ltd. (Atsugi, JP)

Appl. No.: 18/393838

Filed: December 22, 2023

# **Prior Publication Data**

**Document Identifier**US 20240130157 A1

Publication Date
Apr. 18, 2024

# **Foreign Application Priority Data**

| JP | 2013-051231 | Mar. 14, 2013 |
|----|-------------|---------------|
| JP | 2013-093328 | Apr. 26, 2013 |
| JP | 2013-120369 | Jun. 07, 2013 |

# **Related U.S. Application Data**

continuation parent-doc US 17545132 20211208 ABANDONED child-doc US 18393838 continuation parent-doc US 16940460 20200728 US 11201308 20211214 child-doc US 17545132 continuation parent-doc US 16580432 20190924 US 10734596 20200804 child-doc US 16940460 continuation parent-doc US 15948223 20180409 US 10490766 20191126 child-doc US 16580432 continuation parent-doc US 15259325 20160908 US 9978981 20180522 child-doc US 15948223 continuation parent-doc US 14943330 20151117 US 9444020 20160913 child-doc US 15259325 continuation parent-doc US 14620425 20150212 US 9196813 20151124 child-doc US 14943330 continuation parent-doc US 14202810 20140310 US 8956891 20150217 child-doc US 14620425

#### **Publication Classification**

Int. Cl.: H10D86/01 (20250101); H10D86/40 (20250101); H10D86/60 (20250101); H10H20/01 (20250101); H10H20/819 (20250101); H10H20/85 (20250101); H10H20/857 (20250101); H10K50/805 (20230101); H10K59/131 (20230101); H10K71/00 (20230101); H10K71/50 (20230101); H10K71/80 (20230101); H10K77/10 (20230101); H10K59/12 (20230101); H10K102/00 (20230101)

#### **U.S. Cl.:**

CPC H10D86/0214 (20250101); H10D86/40 (20250101); H10D86/60 (20250101); H10H20/01 (20250101); H10H20/819 (20250101); H10H20/8506 (20250101); H10H20/857 (20250101); H10K50/805 (20230201); H10K59/131 (20230201); H10K71/00 (20230201); H10K71/50 (20230201); H10K71/80 (20230201); H10K77/111 (20230201); H01L2224/4847 (20130101); H01L2924/0002 (20130101); H01L2924/12044 (20130101); H10H20/036 (20250101); H10H20/0364 (20250101); H10K59/1201 (20230201); H10K2102/311 (20230201); H01L2924/0002 (20130101); H01L2924/00 (20130101); H01L2924/00 (20130101);

#### **Field of Classification Search**

CPC: H10K (59/131); H10K (59/1201); H10K (71/00); H10K (71/80); H10K (2102/311); H10K (50/805); H10K (59/805); H10K (59/12); H10K (71/40); H10K (71/421); H10K (71/441); H01L (51/56); H01L (51/003); H01L (51/5203); H01L (27/1266); H01L (27/3276); H01L (27/1214); H01L (33/005); H01L (33/483); H01L (33/62); H01L (2227/323); H01L (2227/326); H01L (2251/5338); H01L (77/111); H01L (2924/12044); H01L (2924/00); H01L (2924/0002); H01L (2224/4847); H10D (86/0214); H10D (86/40); H10D (86/60); H10H (20/01); H10H (20/8506); H10H (20/8502); H10H (29/8504); H10H (29/942); H10H (29/857); Y02E (10/549); Y02P (70/50)

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Attorney, Agent or Firm: Robinson Intellectual Property Law Office, P.C.

# **Background/Summary**

#### BACKGROUND OF THE INVENTION

- 1. Field of the Invention
- (1) The present invention relates to a light-emitting device. The present invention also relates to a method for manufacturing the light-emitting device.
- (2) In this specification, a semiconductor device means all types of devices that can function by utilizing semiconductor characteristics, and an electro-optical device, a light-emitting device, a display device, a semiconductor circuit, and an electronic appliance are all semiconductor devices.
- 2. Description of the Related Art
- (3) In recent years, research and development have been extensively conducted on light-emitting elements utilizing electroluminescence (EL). In a basic structure of such a light-emitting element, a layer containing a light-emitting substance is interposed between a pair of electrodes. By applying voltage to the element, light emission from the light-emitting substance can be obtained.
- (4) The above light-emitting element is a self-luminous element; thus, a light-emitting device including the light-emitting element has advantages such as high visibility, no necessity of a backlight, and low power consumption. In addition, the light-emitting device has advantages in that

- it can be manufactured to be thin and lightweight and has fast response speed.
- (5) Since a light-emitting device including the above light-emitting element can be flexible, use of the light-emitting device for a flexible substrate has been proposed.
- (6) As a method for manufacturing a light-emitting device using a flexible substrate, a technique has been developed in which a semiconductor element such as a thin film transistor is manufactured over a substrate such as a glass substrate or a quartz substrate, for example, a space between the semiconductor element and another substrate is filled with an organic resin, and then the semiconductor element is transferred from the glass substrate or the quartz substrate to the other substrate (e.g., a flexible substrate) (Patent Document 1).
- (7) In some cases, over a light-emitting element that has been formed over a flexible substrate, another flexible substrate is provided in order to protect a surface of the light-emitting element or prevent entry of moisture or impurities from the outside.
- (8) Patent Document 2 and Patent Document 3 each disclose technological thought in which a groove is formed in a flexible substrate and part of the flexible substrate is removed along the groove in order to expose a terminal electrode to which an external signal is input. PATENT DOCUMENT
- (9) Patent Document 1: Japanese Published Patent Application No. 2003-174153 Parent Document 2: Japanese Published Patent Application No. 2000-150143 Patent Document 3: Japanese Published Patent Application No. 2009-109770

#### SUMMARY OF THE INVENTION

- (10) In order to supply a signal or electric power to a light-emitting device, it is necessary that part of a flexible substrate be removed to expose a terminal electrode so that an electrode such as a flexible printed circuit (FPC) is connected to the terminal electrode. In addition, it is preferable that the terminal electrode be provided near a display area in order to suppress signal attenuation, electric power attenuation, or the like due to wiring resistance.
- (11) In the case where a flexible substrate is provided over a light-emitting element or a terminal electrode, the flexible substrate is often provided over the light-emitting element or the terminal electrode with a bonding layer provided therebetween. Thus, in the above-described methods disclosed in the patent documents, the bonding layer might remain on the terminal electrode at the time of removal of a portion of the flexible substrate that overlaps the terminal electrode. In addition, the terminal electrode is damaged easily at the time of removal of the bonding layer.
- (12) A method in which part of a flexible substrate is removed by laser light or with an edged tool has a problem in that a terminal electrode included in a light-emitting device is damaged easily and the reliability and manufacturing yield of the light-emitting device are reduced easily. In addition, a display area and a terminal electrode need to be provided with a sufficient space therebetween in order to prevent damage to the display area due to the above-described method; for this reason, signal attenuation, electric power attenuation, or the like due to an increase in wiring resistance is caused easily.
- (13) An object of one embodiment of the present invention is to provide a method for manufacturing a light-emitting device that does not easily damage a terminal electrode.
- (14) Another object of one embodiment of the present invention is to provide a method for manufacturing a light-emitting device that does not easily damage a display area.
- (15) Another object of one embodiment of the present invention is to provide a highly reliable light-emitting device and a method for manufacturing the same.
- (16) Another object of one embodiment of the present invention is to provide a novel light-emitting device and a method for manufacturing the same.
- (17) One embodiment of the present invention is a method for manufacturing a light-emitting device that includes the steps of: forming a light-emitting element and a terminal electrode over an element formation substrate with a separation layer provided therebetween; forming a first substrate having a first opening over the light-emitting element and the terminal electrode with a

bonding layer having a second opening provided therebetween; forming an embedded layer in the openings; forming a transfer substrate over the first substrate and the embedded layer; separating the element formation substrate from the light-emitting element and the terminal electrode; forming a second substrate below the light-emitting element and the terminal electrode; removing the transfer substrate and the embedded layer; forming an anisotropic conductive connection layer in the first opening and the second opening; and forming an external electrode electrically connected to the terminal electrode through the anisotropic conductive connection layer.

- (18) In the method for manufacturing the light-emitting device, the first opening of the first substrate and the second opening of the bonding layer overlap the terminal electrode.
- (19) Using a flexible substrate as the first substrate enables a flexible light-emitting device to be manufactured. Using a flexible substrate as the second substrate enables a flexible light-emitting device to be manufactured.
- (20) It is preferable that the embedded layer be formed using a soluble resin.
- (21) Another embodiment of the present invention is a method for manufacturing a light-emitting device that includes the steps of: forming a light-emitting element and a terminal electrode over an element formation substrate with a separation layer provided therebetween; forming a first substrate over the light-emitting element and the terminal electrode with a first bonding layer provided therebetween; separating the element formation substrate from the light-emitting element and the terminal electrode; forming a second substrate having an opening under the light-emitting element with a second bonding layer provided therebetween; forming an anisotropic conductive connection layer so as to overlap the opening; and forming an external electrode electrically connected to the terminal electrode through the anisotropic conductive connection layer. (22) Another embodiment of the present invention is a method for manufacturing a light-emitting device that includes: a first step of forming a separation layer over an element formation substrate; a second step of forming an insulating layer over the separation layer; a third step of selectively removing part of the insulating layer to form a first opening, in which part of the separation layer is exposed; a fourth step of oxidizing an exposed surface of the separation layer; a fifth step of forming a terminal electrode overlapping the first opening; a sixth step of forming a light-emitting element; a seventh step of forming a first substrate over the light-emitting element and the terminal electrode with a first bonding layer provided therebetween; an eighth step of separating the element formation substrate; a ninth step of forming a second substrate having a second opening under the light-emitting element and the terminal electrode with a second bonding layer provided therebetween; and a tenth step of forming an external electrode electrically connected to the terminal electrode in the second opening. Note that overlap of the first opening with the second opening enables electrical connection between the terminal electrode and the external electrode. (23) Using a flexible substrate as the first substrate enables a flexible light-emitting device to be manufactured. Using a flexible substrate as the second substrate enables a flexible light-emitting
- (24) When attachment of the second substrate having the opening is performed so that the opening overlaps the terminal electrode, a region of the second substrate that overlaps the terminal electrode does not need to be removed by laser light, with an edged tool, or the like; for this reason, a display area and the terminal electrode are not easily damaged. In addition, the distance between the display area and the opening can be shortened; thus, signal attenuation or electrical power attenuation can be suppressed. In addition, the manufacturing process is simplified; thus, the productivity of the light-emitting device can be increased.

device to be manufactured.

(25) One embodiment of the present invention is a light-emitting device that includes a light-emitting element and a terminal electrode over a first substrate, a first layer over the terminal electrode, a second layer over the first layer, and a second substrate having a first portion over the light-emitting element, the first layer, the second layer, and a metal layer with a bonding layer therebetween. The first portion overlaps the terminal electrode, the first layer, and the second layer.

- (26) A flexible substrate is used as the first substrate. A flexible substrate is used as the second substrate.
- (27) The first layer is formed using an organic material. The second layer is formed using a metal material.
- (28) Another embodiment of the present invention is a method for manufacturing a light-emitting device that includes the steps of: forming a light-emitting element and a terminal electrode over an element formation substrate with a separation layer provided therebetween; forming a first layer over the terminal electrode; forming a second layer over the first layer; forming a second substrate having a first portion over the light-emitting element, the terminal electrode, the first layer, and the second layer with a bonding layer provided therebetween so that the first portion overlaps the terminal electrode, the first layer, and the second layer; separating the element formation substrate from the light-emitting element and the terminal electrode; and forming a first substrate under the light-emitting element and the terminal electrode.
- (29) A flexible substrate is used as the first substrate. A flexible substrate is used as the second substrate.
- (30) The first layer is formed using an organic material. The second layer is formed using a metal material.
- (31) Surrounding the first portion with perforations can facilitate separation of the first portion from the second substrate. In addition, the first portion overlaps the first layer and the second layer, whereby the bonding layer that the first portion overlaps can also be removed at the time of the separation of the first portion and the terminal electrode can be exposed easily.
- (32) The exposed terminal electrode can be electrically connected to an external electrode.
- (33) An FPC or a metal wire can be used as the external electrode. In the case of using a metal wire as the external electrode, the metal wire and the terminal electrode can be connected to each other by a wire bonding method or a soldering method without using an anisotropic conductive connection layer.
- (34) One embodiment of the present invention can provide a method for manufacturing a lightemitting device that does not easily damage a terminal electrode.
- (35) One embodiment of the present invention can provide a method for manufacturing a light-emitting device that does not easily damage a display area.
- (36) One embodiment of the present invention can provide a highly reliable light-emitting device and a method for manufacturing the same.
- (37) One embodiment of the present invention can provide a novel light-emitting device and a method for manufacturing the same.

## **Description**

#### BRIEF DESCRIPTION OF THE DRAWINGS

- (1) FIG. **1**A is a top view illustrating a light-emitting device and FIG. **1**B is a cross-sectional view illustrating the same.
- (2) FIGS. **2**A to **2**E are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (3) FIGS. **3**A to **3**C are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (4) FIGS. **4**A and **4**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (5) FIGS. **5**A and **5**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (6) FIGS. 6A and 6B are cross-sectional views illustrating a method for manufacturing a light-

- emitting device.
- (7) FIGS. 7A to 7D are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (8) FIGS. **8**A and **8**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (9) FIGS. **9**A and **9**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (10) FIG. **10**A is a top view illustrating a light-emitting device and FIG. **10**B is a cross-sectional view illustrating the same.
- (11) FIG. **11**A is a perspective view illustrating a light-emitting device and FIG. **11**B is a top view illustrating the same.
- (12) FIG. **12** is a cross-sectional view illustrating a light-emitting device.
- (13) FIGS. **13**A to **13**D are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (14) FIGS. **14**A to **14**D are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (15) FIGS. **15**A to **15**C are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (16) FIG. **16**A is a perspective view illustrating a light-emitting device and FIG. **16**B is a cross-sectional view illustrating the same.
- (17) FIG. **17**A is a perspective view illustrating a light-emitting device and FIG. **17**B is a cross-sectional view illustrating the same.
- (18) FIGS. **18**A and **18**B are perspective views illustrating a light-emitting device and FIGS. **18**C and **18**D are cross-sectional views illustrating the same.
- (19) FIGS. **19**A and **19**B are perspective views illustrating a light-emitting device and FIG. **19**C is a cross-sectional view illustrating the same.
- (20) FIG. **20**A is a perspective view illustrating a light-emitting device and FIG. **20**B is a cross-sectional view illustrating the same.
- (21) FIGS. **21**A to **21**E are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (22) FIGS. **22**A and **22**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (23) FIGS. **23**A and **23**B are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (24) FIGS. **24**A to **24**C are cross-sectional views illustrating a method for manufacturing a light-emitting device.
- (25) FIGS. **25**A to **25**E illustrate arrangement examples of grooves.
- (26) FIGS. **26**A to **26**E illustrate arrangement examples of grooves.
- (27) FIG. **27**A is a perspective view illustrating a light-emitting device and FIG. **27**B is a cross-sectional view illustrating the same.
- (28) FIGS. **28**A and **28**B illustrate structure examples of light-emitting elements.
- (29) FIGS. **29**A to **29**E illustrate examples of electronic appliances and lighting devices.
- (30) FIGS. **30**A and **30**B illustrate an example of an electronic appliance.

#### DETAILED DESCRIPTION OF THE INVENTION

(31) Embodiments will be described in detail with reference to the accompanying drawings. Note that the present invention is not limited to the description below, and it is understood easily by those skilled in the art that various changes and modifications can be made without departing from the spirit and scope of the present invention. Therefore, the present invention should not be construed as being limited to the description in the following embodiments. In the structures of the present invention to be described below, the same portions or portions having similar functions are

- denoted by the same reference numerals in different drawings, and explanation thereof will not be repeated.
- (32) Note that in each drawing referred to in this specification, the size of each component or the thickness of each layer might be exaggerated or a region might be omitted for clarity of the invention. Therefore, embodiments of the invention are not limited to such scales. Especially in a top view, some components might not be illustrated for easy understanding.
- (33) The position, size, range, and the like of each component illustrated in the drawings and the like are not accurately represented in some cases to facilitate understanding of the invention. Therefore, the disclosed invention is not necessarily limited to the position, the size, range, and the like disclosed in the drawings and the like.
- (34) Note that ordinal numbers such as "first" and "second" in this specification and the like are used in order to avoid confusion among components and do not denote the priority or the order such as the order of steps or the stacking order. A term without an ordinal number in this specification and the like might be provided with an ordinal number in a claim in order to avoid confusion among components. In addition, a term with an ordinal number in this specification and the like might be provided with a different ordinal number in a claim. Moreover, an ordinal number provided for a term in this specification and the like might be omitted in a claim.
- (35) In addition, in this specification and the like, the term such as an "electrode" or a "wiring" does not limit a function of a component. For example, an "electrode" is used as part of a "wiring" in some cases, and vice versa. Further, the term "electrode" or "wiring" can also mean a combination of a plurality of "electrodes" and "wirings" formed in an integrated manner.
- (36) Note that the term "over" or "under" in this specification and the like does not necessarily mean that a component is placed "directly on" or "directly below" and "directly in contact with" another component. For example, the expression "electrode B over insulating layer A" does not necessarily mean that the electrode B is on and in direct contact with the insulating layer A and can mean the case where another component is provided between the insulating layer A and the electrode B.

- (37) A structure example of a light-emitting device **100** of one embodiment of the present invention is described with reference to FIGS. **1**A and **1**B. FIG. **1**A is a top view of the light-emitting device **100** and FIG. **1**B is a cross-sectional view taken along the dashed-dotted line A**1**-A**2** in FIG. **1**A. Note that the light-emitting device **100** disclosed in this specification is a display device in which a light-emitting element is used as a display element.
- (38) <Structure of Light-Emitting Device>
- (39) The light-emitting device **100** described in this embodiment includes an electrode **115**, an EL layer **117**, an electrode **118**, a partition **114**, and a terminal electrode **116**. The electrode **115** and the terminal electrode **116** are electrically connected to each other. In addition, in the light-emitting device **100**, the partition **114** is formed over the electrode **115**, the EL layer **117** is formed over the electrode **115** and the partition **114**, and the electrode **118** is formed over the EL layer **117**.
- (40) A light-emitting element **125** includes the electrode **115**, the EL layer **117**, and the electrode **118**. In addition, the light-emitting element **125** is formed over a substrate **111** with a bonding layer **112**, a separation layer **113**, and a base layer **119** provided therebetween. Note that a plurality of light-emitting elements **125** are provided in a display area **131**.
- (41) In the light-emitting device **100** described in this embodiment, a substrate **121** is formed over the electrode **118** with a bonding layer **120** provided therebetween. The substrate **121** has an opening **122***a* overlapping the terminal electrode **116**. The bonding layer **120** has an opening **122***b* that the opening **122***a* overlaps. In this specification, the opening **122***a* and the opening **122***b* are collectively called an opening **122**. In the opening **122**, an external electrode **124** and the terminal electrode **116** are electrically connected to each other through an anisotropic conductive connection layer **123**.

- (42) A switching element for controlling a signal supplied to the light-emitting element **125** may be provided between the light-emitting element **125** and the terminal electrode **116**. For example, a transistor may be provided between the light-emitting element **125** and the terminal electrode **116**. (43) A transistor is a kind of semiconductor element and enables amplification of current or voltage, switching operation for controlling conduction or non-conduction, or the like. By providing a transistor between the light-emitting element **125** and the terminal electrode **116**, the area of the display area **131** can be increased easily and a higher-resolution display can be achieved easily. Note that a resistor, an inductor, a capacitor, or the like, without limitation to a switching element such as a transistor, can be provided in the display area **131**.
- (45) An organic resin material, a glass material that is thin enough to have flexibility, or the like can be used for the substrate 111 and the substrate 121. In the case where the light-emitting device 100 is a bottom-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer 117 is used for the substrate 111. In the case where the light-emitting device 100 is a top-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer 117 is used for the substrate 121. (46) As a material that has flexibility and transmits visible light, which can be used for the substrate 111 and the substrate 121, the following can be used: a polyethylene terephthalate resin, a polyethylene naphthalate resin, a polyacrylonitrile resin, a polyimide resin, a polyamide resin, a polyvinylchloride resin, or the like.
- (47) The thermal expansion coefficients of the substrate **111** and the substrate **121** are preferably less than or equal to 30 ppm/K, more preferably less than or equal to 10 ppm/K. In addition, on surfaces of the substrate **111** and the substrate **121**, a protective film having low water permeability may be formed in advance; examples of the protective film include a film containing nitrogen and silicon such as a silicon nitride film or a silicon oxynitride film and a film containing nitrogen and aluminum such as an aluminum nitride film. Note that a structure in which a fibrous body is impregnated with an organic resin (also called prepreg) may be used as the substrate **111** and the substrate **121**.
- (48) <Base Layer>

(44) <Substrates>

- (49) The base layer **119** is preferably formed as a single layer or a multilayer using silicon oxide, silicon nitride, silicon oxynitride, silicon nitride oxide, aluminum oxide, aluminum oxynitride, aluminum nitride oxide, or the like. The base layer **119** can be formed by a sputtering method, a CVD method, a thermal oxidation method, a coating method, a printing method, or the like. (50) The base layer **119** can prevent or reduce diffusion of impurity elements from the substrate **111**, the bonding layer **112**, or the like to the light-emitting element **125**.
- (51) <Terminal Electrode>
- (52) The terminal electrode **116** can be formed using a conductive material. For example, a metal element selected from aluminum, chromium, copper, silver, gold, platinum, tantalum, nickel, titanium, molybdenum, tungsten, hafnium (Hf), vanadium (V), niobium (Nb), manganese, magnesium, zirconium, beryllium, and the like; an alloy containing any of the above metal elements; an alloy containing a combination of the above metal elements; or the like can be used. A semiconductor typified by polycrystalline silicon including an impurity element such as phosphorus, or silicide such as nickel silicide may also be used. There is no particular limitation on the formation method of the conductive material, and a variety of formation methods such as an evaporation method, a CVD method, a sputtering method, and a spin coating method can be employed.
- (53) The terminal electrode **116** can also be formed using a conductive material containing oxygen, such as indium tin oxide, indium oxide containing tungsten oxide, indium zinc oxide containing

tungsten oxide, indium oxide containing titanium oxide, indium tin oxide containing titanium oxide, indium zinc oxide, or indium tin oxide to which silicon oxide is added. It is also possible to use a stacked-layer structure formed using the above conductive material containing oxygen and a material containing the above metal element.

- (54) The terminal electrode **116** may have a single-layer structure or a stacked-layer structure of two or more layers. For example, a single-layer structure of an aluminum layer containing silicon, a two-layer structure in which a titanium layer is stacked over an aluminum layer, a two-layer structure in which a tingsten layer is stacked over a titanium nitride layer, a two-layer structure in which a tungsten layer is stacked over a titanium nitride layer, and a three-layer structure in which a titanium layer, an aluminum layer, and a titanium layer are stacked in this order are given. Alternatively, a layer, an alloy layer, or a nitride layer containing aluminum and one or more elements selected from titanium, tantalum, tungsten, molybdenum, chromium, neodymium, and scandium may be used.
- (55) <Electrode **115**>
- (56) The electrode **115** is preferably formed using a conductive material that efficiently reflects light emitted from the EL layer **117** formed later. Note that the electrode **115** may have a stacked-layer structure of a plurality of layers without limitation to a single-layer structure. For example, in the case where the electrode **115** is used as an anode, a layer in contact with the EL layer **117** may be a light-transmitting layer, such as an indium tin oxide layer, having a work function higher than that of the EL layer **117** and a layer having high reflectance (e.g., aluminum, an alloy containing aluminum, or silver) may be provided in contact with the layer.
- (57) The light-emitting device having a top emission structure is described as an example in this embodiment. In the case of a light-emitting device having a bottom emission structure or a dual emission structure, the electrode **115** may be formed using a light-transmitting conductive material. (58) <Partition>
- (59) The partition **114** is provided in order to prevent an electrical short circuit between the adjacent electrodes **118**. In the case of using a metal mask for formation of the EL layer **117** described later, the partition **114** has a function of preventing the contact of metal mask with a region where the light-emitting element **125** is formed. The partition **114** can be formed of an organic resin material such as an epoxy resin, an acrylic resin, or an imide resin or an inorganic material such as silicon oxide. The partition **114** is preferably formed so that its sidewall has a tapered shape or a tilted surface with a continuous curvature. The sidewall of the partition **114** having the above-described shape enables favorable coverage with the EL layer **117** and the electrode **118** formed later.
- (60) <EL Layer>
- (61) A structure of the EL layer **117** is described in Embodiment 9.
- (62) <Electrode **118**>
- (63) The electrode **118** is used as a cathode in this embodiment, and thus is preferably formed using a material that has a low work function and can inject electrons into the EL layer **117** described later. As well as a single-layer of a metal having a low work function, a stack in which a metal material such as aluminum, a conductive oxide material such as indium tin oxide, or a semiconductor material is formed over a several-nanometer-thick buffer layer formed of an alkali metal or an alkaline earth metal having a low work function may be used as the electrode **118**. As the buffer layer, an oxide of an alkaline earth metal, a halide, a magnesium-silver alloy, or the like can also be used.
- (64) In the case where light emitted from the EL layer **117** is extracted through the electrode **118**, the electrode **118** preferably has a property of transmitting visible light.
- (65) <Bonding Layers>
- (66) The bonding layer **120** is in contact with the electrode **118** in this embodiment. The substrate

- **121** is fixed by the bonding layer **120**. The bonding layer **112** is in contact with the separation layer **113**. The substrate **111** is fixed by the bonding layer **112**. A light curable adhesive, a reaction curable adhesive, a thermosetting adhesive, or an anaerobic adhesive can be used as the bonding layer **120** and the bonding layer **112**. For example, an epoxy resin, an acrylic resin, or an imide resin can be used. A drying agent (e.g., zeolite) having a size less than or equal to the wavelength of light or a filler (e.g., titanium oxide or zirconium) with a high refractive index is preferably mixed into the bonding layer **120** in the case of a top emission structure or into the bonding layer **112** in the case of a bottom emission structure, in which case the efficiency of extracting light emitted from the EL layer **117** can be improved.
- (67) <Separation Layer>
- (68) The separation layer **113** can be formed using an element selected from tungsten, molybdenum, titanium, tantalum, niobium, nickel, cobalt, zirconium, ruthenium, rhodium, palladium, osmium, iridium, and silicon; an alloy material containing any of the elements; or a compound material containing any of the elements. The separation layer **113** can also be formed to have a single-layer structure or a stacked-layer structure using any of the materials. Note that the crystalline structure of the separation layer **113** may be amorphous, microcrystalline, or polycrystalline. The separation layer **113** can also be formed using a metal oxide such as aluminum oxide, gallium oxide, zinc oxide, titanium dioxide, indium oxide, indium tin oxide, indium zinc oxide, or InGaZnO (IGZO).
- (69) The separation layer **113** can be formed by a sputtering method, a CVD method, a coating method, a printing method, or the like. Note that the coating method includes a spin coating method, a droplet discharge method, and a dispensing method.
- (70) In the case where the separation layer **113** has a single-layer structure, the separation layer **113** is preferably formed using tungsten, molybdenum, or a tungsten-molybdenum alloy. Alternatively, the separation layer **113** is preferably formed using an oxide or oxynitride of tungsten, an oxide or oxynitride of molybdenum, or an oxide or oxynitride of a tungsten-molybdenum alloy.
- (71) In the case where the separation layer **113** has a stacked-layer structure including, for example, a layer containing tungsten and a layer containing an oxide of tungsten, the layer containing an oxide of tungsten may be formed as follows: the layer containing tungsten is formed first and then an insulating oxide layer is formed in contact therewith, so that the layer containing an oxide of tungsten is formed at the interface between the layer containing tungsten and the insulating oxide layer. Alternatively, the layer containing an oxide of tungsten may be formed by performing thermal oxidation treatment, oxygen plasma treatment, treatment with a highly oxidizing solution such as ozone water, or the like on the surface of the layer containing tungsten.
- (72) < Anisotropic Conductive Connection Layer>
- (73) The anisotropic conductive connection layer **123** can be formed using any of various kinds of anisotropic conductive films (ACF), anisotropic conductive pastes (ACP), and the like.
- (74) The anisotropic conductive connection layer **123** is formed by curing a paste-form or sheet-form material that is obtained by mixing conductive particles to a thermosetting resin or a thermosetting, light curable resin. The anisotropic conductive connection layer **123** exhibits an anisotropic conductive property by light irradiation or thermocompression bonding. As the conductive particles used for the anisotropic conductive connection layer **123**, for example, particles of a spherical organic resin coated with a thin-film metal such as Au, Ni, or Co can be used.
- (75) < Method for Manufacturing Light-Emitting Device>
- (76) Next, a method for manufacturing the light-emitting device **100** is described with reference to FIGS. **2**A to **2**E, FIGS. **3**A to **3**C, FIGS. **4**A and **4**B, FIGS. **5**A and **5**B, and FIGS. **6**A and **6**B.
- FIGS. **2**A to **6**B are cross-sectional views taken along the dashed-dotted line A**1**-A**2** in FIG. **1**A.
- (77) < Formation of Separation Layer>
- (78) First, the separation layer **113** is formed over an element formation substrate **101** (see FIG.

- **2**A). Note that the element formation substrate **101** may be a glass substrate, a quartz substrate, a sapphire substrate, a ceramic substrate, a metal substrate, or the like. Alternatively, the element formation substrate **101** may be a plastic substrate having heat resistance to the processing temperature in this embodiment.
- (79) As the glass substrate, for example, a glass material such as aluminosilicate glass, aluminoborosilicate glass, or barium borosilicate glass is used. Note that when the glass substrate contains a large amount of barium oxide (BaO), the glass substrate can be heat-resistant and more practical. Alternatively, crystallized glass or the like may be used.
- (80) In this embodiment, the separation layer **113** is formed of tungsten by a sputtering method.
- (81) <Formation of Base Layer>
- (82) Next, the base layer **119** is formed over the separation layer **113** (see FIG. **2**A). In this embodiment, the base layer **119** is formed of silicon oxide by a plasma CVD method.
- (83) < Formation of Terminal Electrode>
- (84) Next, the terminal electrode **116** is formed over the base layer **119**. First, a three-layer metal film in which aluminum is interposed between two layers of molybdenum is formed over the base layer **119** by a sputtering method. After that, a resist mask is formed over the metal film, and the metal film is etched into a desired shape with the use of the resist mask. In the above-described manner, the terminal electrode **116** can be formed. The resist mask can be formed by a photolithography method, a printing method, an inkjet method, or the like as appropriate. Formation of the resist mask by an inkjet method needs no photomask; thus, manufacturing costs can be reduced.
- (85) The metal film may be etched by either a dry etching method or a wet etching method, or by both a dry etching method and a wet etching method. In the case where the metal film is etched by a wet etching method, a solution obtained by mixing phosphoric acid, acetic acid, and nitric acid, a solution containing oxalic acid, a solution containing phosphoric acid, or the like can be used as an etchant. After the etching treatment, the resist mask is removed (see FIG. 2B).
- (86) < Formation of Electrode **115**>
- (87) Next, the electrode **115** is formed over the base layer **119**. The electrode **115** can be formed in a manner similar to that of the terminal electrode **116**. In this embodiment, the electrode **115** is formed using a material in which indium tin oxide is stacked over silver. The electrode **115** and the terminal electrode **116** are electrically connected to each other (see FIG. **2B**).
- (88) <Formation of Partition>
- (89) Next, the partition **114** is formed (see FIG. **2**C). In this embodiment, the partition **114** is formed in such a manner that a photosensitive organic resin material is applied by a coating method and processed into a desired shape. In this embodiment, the partition **114** is formed using a photosensitive imide resin.
- (90) <Formation of EL Layer>
- (91) Next, the EL layer 117 is formed over the electrode 115 and the partition 114 (see FIG. 2D).
- (92) < Formation of Electrode 118>
- (93) Next, the electrode **118** is formed in contact with the EL layer **117**. The electrode **118** can be formed by an evaporation method, a sputtering method, or the like (see FIG. **2**E).
- (94) <Formation of Substrate>
- (95) Next, the substrate **121** having the opening **122***a* is formed over the electrode **118** with the bonding layer **120** provided therebetween. At this time, the opening **122***a* of the substrate **121** is positioned so as to overlap the terminal electrode **116**. The bonding layer **120** has the opening **122***b* that the opening **122***a* overlaps. As described above, the opening **122***a* and the opening **122***b* are collectively called the opening **122** in this specification (see FIG. **3**A).
- (96) < Formation of Embedded Layer>
- (97) Next, an embedded layer **109** is formed in the opening **122** (see FIG. **3**B). In the case where the embedded layer **109** is not formed in the opening **122**, a region of the terminal electrode **116**

- that the opening **122** overlaps might be damaged at the time of separation of the element formation substrate **101** performed later. Note that the embedded layer **109** is removed later, and thus is preferably formed using a material that is soluble in water or an organic solvent. As such a material, a soluble resin such as a soluble acrylic resin, a soluble polyimide resin, or a soluble epoxy resin can be used. In addition, it is preferable that the level of a surface of the embedded layer **109** be substantially the same as that of a surface of the substrate **121**. A soluble acrylic resin is used as the embedded layer **109** in this embodiment.
- (98) < Formation of Transfer Substrate >
- (99) Next, a transfer substrate **102** is attached onto the substrate **121** (see FIG. **3**C). The transfer substrate **102** is removed later, and thus can be formed of a UV tape or a dicing tape whose adhesion is reduced by irradiation with ultraviolet light, a tape whose adhesion is reduced by heating, or a low-viscosity tape. In this embodiment, a UV tape is used as the transfer substrate **102**.
- (100) <Separation of Substrate>
- (101) Next, the element formation substrate **101** and the separation layer **113** are separated from the base layer **119** (see FIG. **4**A). As a separation method, mechanical force (a separation process with a human hand or a gripper, a separation process by rotation of a roller, ultrasonic waves, or the like) may be used. For example, a cut is made in the separation layer **113** with a sharp edged tool, by laser light irradiation, or the like and water is injected into the cut. A portion between the separation layer **113** and the base layer **119** absorbs water through capillarity action, so that the element formation substrate **101** can be separated easily.
- (102) < Attachment of Light-Emitting Device and Substrate>
- (103) Next, the substrate **111** is attached to the base layer **119** with the bonding layer **112** provided therebetween (see FIG. **4**B).
- (104) <Separation of Transfer Substrate>
- (105) Next, the transfer substrate **102** is separated. The transfer substrate **102** is formed of a UV tape in this embodiment. Thus, by irradiation with ultraviolet light **103** (see FIG. **5**A), the transfer substrate **102** can be separated easily (see FIG. **5**B).
- (106) < Removal of Embedded Layer>
- (107) Next, the embedded layer **109** is removed with a solvent that is suitable for removal of the embedded layer **109**, such as water or an organic solvent (see FIG. **6**A).
- (108) < Formation of External Electrode>
- (109) Next, the anisotropic conductive connection layer **123** is formed in the opening **122**. In addition, the external electrode **124** for inputting electric power or a signal to the light-emitting device **100** is formed at the position over the opening **122**, which overlaps the terminal electrode **116** (see FIG. **6**B). The external electrode **124** is electrically connected to the terminal electrode **116** through the anisotropic conductive connection layer **123**. Thus, electric power or a signal can be input to the light-emitting device **100**. Note that an FPC can be used as the external electrode **124**.
- (110) Note that a metal wire can also be used as the external electrode **124**. The metal wire and the terminal electrode **116** can be connected to each other by a wire bonding method without using the anisotropic conductive connection layer **123**. Alternatively, the metal wire and the terminal electrode **116** can be connected to each other by a soldering method.
- (111) In one embodiment of the present invention, removal of part of the substrate **121** by laser light or with an edged tool for inputting electric power or a signal to the light-emitting device **100** is not needed; thus, the light-emitting device **100** and the terminal electrode **116** are not easily damaged. One embodiment of the present invention can provide a highly reliable light-emitting device having high manufacturing yield.
- (112) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (113) In this embodiment, a method for manufacturing the light-emitting device **100**, which is different from the method disclosed in Embodiment 1, is described. Note that description is made mainly on portions different from those in Embodiment 1 to avoid repeated description.
- (114) < Method for Manufacturing Light-Emitting Device>
- (115) The manufacturing method can be performed in a manner similar to that described in Embodiment 1 until the formation of the partition **114** (see FIG. **2**C).
- (116) < Formation of EL Layer>
- (117) Next, the EL layer **117** is formed over the electrode **115** and the partition **114**. At the same time as the EL layer **117**, a layer **104** is formed in a region on the terminal electrode **116** that the opening **122** is to overlap (see FIG. **7**A). The layer **104** can be formed using a material and a method similar to those of the EL layer **117**.
- (118) < Formation of Electrode **118**>
- (119) Next, the electrode **118** is formed in contact with the EL layer **117**. At this time, a layer **105** is formed in a region on the layer **104** that the opening **122** is to overlap. The layer **105** can be formed using part of a layer formed at the same time as the electrode **118** (see FIG. **7**B).
- (120) < Formation of Substrate **121**>
- (121) Next, the substrate **121** is formed over the electrode **118** with the bonding layer **120** provided therebetween. At this time, the opening **122** of the substrate **121** is positioned so as to overlap the terminal electrode **116**, the layer **105**, and the layer **104** (see FIG. **7**C). Note that the bonding layer **120** is not formed in a region that the opening **122** overlaps, which means that the bonding layer **120** also has an opening that the opening **122** overlaps.
- (122) Note that the layer **104** is formed to have a size with which the outer edge of the layer **104** is located outside the opening of the bonding layer when seen from the top. In addition, the layer **105** is formed to have a size with which the outer edge of the layer **105** is located inside the opening of the bonding layer when seen from the top.
- (123) < Formation of Embedded Layer and Transfer Substrate>
- (124) Next, the embedded layer **109** and the transfer substrate **102** are each formed in a manner similar to that in Embodiment 1 (see FIG. 7D). Then, the element formation substrate **101** is separated, and the substrate **111** is attached to the base layer **119** with the bonding layer **112** provided therebetween.
- (125) < Separation of Transfer Substrate>
- (126) Next, the transfer substrate **102** is irradiated with ultraviolet light **103** to weaken the adhesion of the transfer substrate **102**, so that the transfer substrate **102** is separated. Before the irradiation with the ultraviolet light **103**, a mask **107** is provided in a region of the transfer substrate **102** that overlaps the embedded layer **109** in order to prevent irradiation of the region with the ultraviolet light **103** (see FIG. **8**A).
- (127) By providing the mask **107** in the above-described manner, the adhesion of the region of the transfer substrate **102** that overlaps the embedded layer **109** is maintained without being reduced. Since the adhesion of the interface between the layer **104** and the layer **105** is low, the embedded layer **109** and the layer **105** can also be removed at the time of the separation of the transfer substrate **102** (see FIG. **8**B).
- (128) < Removal of Layer **104**>
- (129) Next, the layer **104** is removed with an organic solvent such as ethyl alcohol to expose part of a surface of the terminal electrode **116** (see FIG. **9**A).
- (130) < Formation of External Electrode>
- (131) Next, the anisotropic conductive connection layer **123** is formed in the opening **122**, and the external electrode **124** for inputting electric power or a signal to the light-emitting device **100** is formed over the anisotropic conductive connection layer **123** (see FIG. **9**B). The external electrode **124** and the terminal electrode **116** are electrically connected to each other through the anisotropic

- conductive connection layer **123**. Thus, electric power or a signal can be supplied or input to the light-emitting device **100**. Note that an FPC can be used as the external electrode **124**.
- (132) In one embodiment of the present invention, removal of part of the substrate **121** for inputting electric power or a signal to the light-emitting device **100** is not needed; thus, the light-emitting device **100** and the terminal electrode **116** are not easily damaged. One embodiment of the present invention can provide a highly reliable light-emitting device having high manufacturing yield.
- (133) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (134) In this embodiment, a light-emitting device **200** having a structure different from the structure of the light-emitting device **100** described in the above embodiment is described with reference to FIGS. **10**A and **10**B. FIG. **10**A is a top view of the light-emitting device **200**, and FIG. **10**B is a cross-sectional view taken along the dashed-dotted line B**1**-B**2** in FIG. **10**A.
- (135) < Structure of Light-Emitting Device>
- (136) The light-emitting device **200** described in this embodiment includes a display area **231** and a peripheral circuit **251**. The light-emitting device **200** also includes a terminal electrode **216** and the light-emitting element **125** including the electrode **115**, the EL layer **117**, and the electrode **118**. A plurality of light-emitting elements **125** are formed in the display area **231**. A transistor **232** for controlling the amount of light emitted from the light-emitting element **125** is connected to each light-emitting element **125**.
- (137) The terminal electrode **216** is electrically connected to the external electrode **124** through the anisotropic conductive connection layer **123** formed in the opening **122**. In addition, the terminal electrode **216** is electrically connected to the peripheral circuit **251**.
- (138) The peripheral circuit **251** includes a plurality of transistors **252**. The peripheral circuit **251** has a function of determining which of the light-emitting elements **125** in the display area **231** is supplied with a signal from the external electrode **124**.
- (139) In the light-emitting device **200** illustrated in FIGS. **10**A and **10**B, the substrate **111** and the substrate **121** are attached to each other with the bonding layer **120** provided therebetween. An insulating layer **205** is formed over the substrate **111** with the bonding layer **112** provided therebetween. The insulating layer **205** is preferably formed as a single layer or a multilayer using any of silicon oxide, silicon nitride, silicon oxynitride, silicon nitride oxide, aluminum oxide, aluminum oxynitride, and aluminum nitride oxide. The insulating layer **205** can be formed by a sputtering method, a CVD method, a thermal oxidation method, a coating method, a printing method, or the like.
- (140) Note that the insulating layer **205** functions as a base layer and can prevent or reduce diffusion of impurity elements from the substrate **111**, the bonding layer **112**, or the like to the transistor or the light-emitting element.
- (141) In addition, the transistor **232**, the transistor **252**, the terminal electrode **216**, and a wiring **219** are formed over the insulating layer **205**. Note that although a channel-etched transistor that is a type of bottom-gate transistor is illustrated as the transistor **232** and the transistor **252** in this embodiment, a channel-protective transistor, a top-gate transistor, or the like can also be used. It is also possible to use a dual-gate transistor, in which a semiconductor layer in which a channel is formed is interposed between two gate electrodes.
- (142) The transistor **232** and the transistor **252** may have the same structure. However, the size (e.g., channel length and channel width) or the like of each transistor can be adjusted as appropriate.
- (143) The transistor **232** and the transistor **252** each include a gate electrode **206**, a gate insulating layer **207**, a semiconductor layer **208**, a source electrode **209***a*, and a drain electrode **209***b*.
- (144) The terminal electrode **216**, the wiring **219**, the gate electrode **206**, the source electrode **209***a*,

- and the drain electrode **209***b* can be formed using a material and a method similar to those of the terminal electrode **116**. In addition, the gate insulating layer **207** can be formed using a material and a method similar to those of the insulating layer **205**.
- (145) The semiconductor layer **208** can be formed using an amorphous semiconductor, a microcrystalline semiconductor, a polycrystalline semiconductor, or the like. For example, amorphous silicon or microcrystalline germanium can be used. Alternatively, a compound semiconductor such as silicon carbide, gallium arsenide, an oxide semiconductor, or a nitride semiconductor, an organic semiconductor, or the like can be used.
- (146) Note that an oxide semiconductor has an energy gap as wide as 3.0 eV or more and high visible-light transmissivity. In a transistor obtained by processing an oxide semiconductor under appropriate conditions, the off-state current at ambient temperature (e.g., 25° C.) can be less than or equal to 100 zA (1×10.sup.-19 A), less than or equal to 10 zA (1×10.sup.-20 A), and further less than or equal to 1 zA (1×10.sup.-21 A). Therefore, a light-emitting device with low power consumption can be achieved.
- (147) In the case where an oxide semiconductor is used for the semiconductor layer **208**, an insulating layer containing oxygen is preferably used as an insulating layer that is in contact with the semiconductor layer **208**.
- (148) In addition, an insulating layer **210** is formed over the transistor **232** and the transistor **252**, and an insulating layer **211** is formed over the insulating layer **210**. The insulating layer **210** functions as a protective insulating layer and can prevent or reduce diffusion of impurity elements from a layer above the insulating layer **210** to the transistor **232** and the transistor **252**. The insulating layer **210** can be formed using a material and a method similar to those of the insulating layer **205**.
- (149) Planarization treatment may be performed on the insulating layer **211** to reduce unevenness of a surface on which the light-emitting element **125** is formed. The planarization treatment may be, but not particularly limited to, polishing treatment (e.g., chemical mechanical polishing (CMP)) or dry etching treatment.
- (150) Forming the insulating layer **211** using an insulating material with a planarization function can omit polishing treatment. As the insulating material with a planarization function, for example, an organic material such as a polyimide resin or an acrylic resin can be used. Other than the above-described organic materials, it is also possible to use a low-dielectric constant material (low-k material) or the like. Note that the insulating layer **211** may be formed by stacking a plurality of insulating films formed of these materials.
- (151) In addition, over the insulating layer **211**, the light-emitting element **125** and the partition **114** for separating the adjacent light-emitting elements **125** are formed.
- (152) In addition, the substrate **121** is provided with a light-shielding film **264**, a coloring layer **266**, and an overcoat layer **268**. The light-emitting device **200** is a top-emission light-emitting device, in which light emitted from the light-emitting element **125** is extracted from the substrate **121** side through the coloring layer **266**.
- (153) The light-emitting element **125** is electrically connected to the transistor **232** through openings formed in the insulating layer **211** and the insulating layer **210**.
- (154) Although an active matrix light-emitting device is described as an example of the light-emitting device in this embodiment, the present invention can also be applied to a passive matrix light-emitting device.
- (155) One embodiment of the present invention can be applied to display devices such as a liquid crystal display device including a liquid crystal element as a display element, an electronic paper, a digital micromirror device (DMD), a plasma display panel (PDP), a field emission display (FED), and a surface-conduction electron-emitter display (SED), without limitation to a light-emitting device including a light-emitting element as a display element.
- (156) An example of a liquid crystal element is an element that controls transmission and non-

transmission of light by optical modulation action of a liquid crystal. The element can include a pair of electrodes and a liquid crystal layer. Note that optical modulation action of a liquid crystal is controlled by an electric field applied to the liquid crystal (including a horizontal electric field, a vertical electric field, and an oblique electric field). The following are specific examples of the liquid crystal: nematic liquid crystal, cholesteric liquid crystal, smectic liquid crystal, discotic liquid crystal, thermotropic liquid crystal, lyotropic liquid crystal, low-molecular liquid crystal, polymer liquid crystal, polymer dispersed liquid crystal (PDLC), ferroelectric liquid crystal, antiferroelectric liquid crystal, main-chain liquid crystal, side-chain polymer liquid crystal, and bananashaped liquid crystal. Moreover, the following methods can be employed for driving the liquid crystal: a twisted nematic (TN) mode, a super twisted nematic (STN) mode, an in-plane-switching (IPS) mode, a fringe field switching (FFS) mode, a multi-domain vertical alignment (MVA) mode, a patterned vertical alignment (PVA) mode, an advanced super view (ASV) mode, an axially symmetric aligned microcell (ASM) mode, an optically compensated birefringence (OCB) mode, an electrically controlled birefringence (ECB) mode, an ferroelectric liquid crystal (FLC) mode, an anti-ferroelectric liquid crystal (AFLC) mode, a polymer dispersed liquid crystal (PDLC) mode, a polymer network liquid crystal (PNLC) mode, a guest-host mode, and a blue phase mode. Note that the present invention is not limited to these examples and any of a variety of liquid crystal elements and driving methods can be applied to the liquid crystal element and the driving method thereof. (157) Display of electronic paper can be performed using, for example, molecules (a method utilizing optical anisotropy, dye molecular orientation, or the like), particles (a method utilizing electrophoresis, particle movement, particle rotation, phase change, or the like), movement of one end of a film, coloring properties or phase change of molecules, optical absorption by molecules, or self-light emission by combination of electrons and holes. Specific examples of a display method of electronic paper include microcapsule electrophoresis, horizontal electrophoresis, vertical electrophoresis, a spherical twisting ball, a magnetic twisting ball, a columnar twisting ball, a charged toner, electronic liquid powder, magnetic electrophoresis, a magnetic thermosensitive type, electro wetting, light-scattering (transparent-opaque change), a cholesteric liquid crystal and a photoconductive layer, cholesteric liquid crystal, bistable nematic liquid crystal, ferroelectric liquid crystal, a liquid crystal dispersed type with a dichroic dye, a movable film, coloring and decoloring properties of a leuco dye, photochromism, electrochromism, electrodeposition, and flexible organic EL. Note that the present invention is not limited to these examples, and various electronic paper and display methods can be used as electronic paper and a display method thereof. Here, with the use of microcapsule electrophoresis, aggregation and precipitation of phoresis particles can be prevented. Electronic liquid powder has advantages such as high-speed response, high reflectivity, wide viewing angle, low power consumption, and memory properties.

(158) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (159) A structure example of a light-emitting device **2100** of one embodiment of the present invention is described with reference to FIGS. **11**A and **11**B and FIG. **12**. FIG. **11**A is a perspective view illustrating an outer appearance of the light-emitting device **2100**, and FIG. **11**B is a top view of the light-emitting device **2100**. FIG. **12** is a cross-sectional view taken along the dashed-dotted line C**1**-C**2** in FIG. **11**A. Note that the light-emitting device **2100** disclosed in this specification is a display device in which a light-emitting element is used as a display element.
- (160) < Structure of Light-Emitting Device>
- (161) The light-emitting device **2100** described in this embodiment includes an electrode **2115**, an EL layer **2117**, an electrode **2118**, a partition **2114**, and a terminal electrode **2116**. The electrode **2115** and the terminal electrode **2116** are electrically connected to each other. In the light-emitting device **2100**, the partition **2114** is provided over the electrode **2115**, the EL layer **2117** is provided over the electrode **2115** and the partition **2114**, and the electrode **2118** is provided over the EL layer

#### 2117.

- (162) A light-emitting element **2125** includes the electrode **2115**, the EL layer **2117**, and the electrode **2118**. The light-emitting element **2125** is formed over a substrate **2111** with a bonding layer **2112** and a base layer **2119** provided therebetween. Note that a plurality of light-emitting elements **2125** are provided in a display area **2131**.
- (163) In addition, in the light-emitting device **2100** described in this embodiment, a substrate **2121** is formed over the electrode **2118** with a bonding layer **2120** provided therebetween.
- (164) The base layer **2119** has an opening **2122***a* that the terminal electrode **2116** overlaps. The bonding layer **2112** and the substrate **2111** have an opening **2122***b* that the opening **2122***a* overlaps. In this specification, the opening **2122***a* and the opening **2122***b* are collectively called an opening **2122**. An external electrode **2124** and the terminal electrode **2116** are electrically connected to each other through an anisotropic conductive connection layer **2123** in the opening **2122**.
- (165) A switching element for controlling a signal supplied to the light-emitting element **2125** may be provided between the light-emitting element **2125** and the terminal electrode **2116**. For example, a transistor may be provided between the light-emitting element **2125** and the terminal electrode **2116**.
- (166) A transistor is a kind of semiconductor element and enables amplification of current or voltage, switching operation for controlling conduction or non-conduction, or the like. By providing a transistor between the light-emitting element 2125 and the terminal electrode 2116, the area of the display area 2131 can be increased easily and a higher-resolution display can be achieved easily. Note that without limitation to a switching element such as a transistor, a resistor, an inductor, a capacitor, or the like can be provided in the display area 2131.
- (167) <Substrates>
- (168) The substrate **2121** and the substrate **2111** can be formed using materials similar to those of the substrate **121** and the substrate **111** disclosed in the above embodiment. In the case where the light-emitting device **2100** is a bottom-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer **2117** is used for the substrate **2111**. In the case where the light-emitting device **2100** is a top-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer **2117** is used for the substrate **2121**.
- (169) <Base Layer>
- (170) The base layer **2119** can be formed using a material and a method similar to those of the base layer **119** disclosed in the above embodiment.
- (171) The base layer **2119** can prevent or reduce diffusion of impurity elements from the substrate **2111**, the bonding layer **2112**, or the like to the light-emitting element **2125**.
- (172) <Terminal Electrode>
- (173) The terminal electrode **2116** can be formed using a material and a method similar to those of the terminal electrode **116** disclosed in the above embodiment.
- (174) <Electrode **2115**>
- (175) The electrode **2115** is preferably formed using a conductive material that efficiently reflects light emitted from the EL layer **2117** formed later. The electrode **2115** can be formed using a material and a method similar to those of the electrode **115** disclosed in the above embodiment. (176) The light-emitting device having a top emission structure is described as an example in this embodiment. In the case of a light-emitting device having a bottom emission structure or a dual
- embodiment. In the case of a light-emitting device having a bottom emission structure or a dual emission structure, the electrode **2115** may be formed using a light-transmitting conductive material.
- (177) < Partition>
- (178) The partition **2114** is provided in order to prevent an electrical short circuit between the adjacent electrodes **2118**. In the case of using a metal mask for formation of the EL layer **2117** described later, the partition **2114** has a function of preventing contact of the metal mask with a

region where the light-emitting element **2125** is formed. The partition **2114** can be formed using a material and a method similar to those of the partition **114** disclosed in the above embodiment. The partition **2114** is preferably formed so that its sidewall has a tapered shape or a tiled surface with a continuous curvature. The sidewall of the partition **2114** having the above-described shape enables favorable coverage with the EL layer **2117** and the electrode **2118** formed later.

- (179) <EL Layer>
- (180) A structure of the EL layer **2117** is described in Embodiment 9.
- (181) < Electrode **2118**>
- (182) The electrode **2118** is used as a cathode in this embodiment, and thus is preferably formed using a material that has a low work function and can inject electrons into the EL layer **2117** described later. The electrode **2118** can be formed using a material and a method similar to those of the electrode **118** disclosed in the above embodiment.
- (183) In the case where light emitted from the EL layer **2117** is extracted through the electrode **2118**, the electrode **2118** preferably has a property of transmitting visible light.
- (184) <Bonding Layers>
- (185) The bonding layer **2120** is in contact with the electrode **2118** in this embodiment. The substrate **2121** is fixed by the bonding layer **2120**. The bonding layer **2112** is in contact with the base layer **2119**. The substrate **2111** is fixed by the bonding layer **2112**. The bonding layer **2120** and the bonding layer **2112** can be formed using a material and a method similar to those of the bonding layer **120** and the bonding layer **112** disclosed in the above embodiment. A drying agent (e.g., zeolite) having a size less than or equal to the wavelength of light or a filler (e.g., titanium oxide or zirconium) with a high refractive index is preferably mixed into the bonding layer **2120** in the case of a top emission structure or into the bonding layer **2112** in the case of a bottom emission structure, in which case the efficiency of extracting light emitted from the EL layer **2117** can be improved.
- (186) < Anisotropic Conductive Connection Layer>
- (187) The anisotropic conductive connection layer **2123** can be formed using a material and a method similar to those of the anisotropic conductive connection layer **123** disclosed in the above embodiment.
- (188) < Method for Manufacturing Light-Emitting Device>
- (189) Next, an example of a method for manufacturing the light-emitting device **2100** is described with reference to FIGS. **13**A to **13**D, FIGS. **14**A to **14**D, and FIGS. **15**A to **15**C. FIGS. **13**A to **15**C are cross-sectional views taken along the dashed-dotted line C**1**-C**2** in FIGS. **11**A and **11**B.
- (190) < Formation of Separation Layer>
- (191) First, a separation layer **2113** is formed over an element formation substrate **2101** (see FIG.
- **13**A). Note that the element formation substrate **2101** can be formed using a material similar to that of the element formation substrate **101** disclosed in the above embodiment.
- (192) The separation layer **2113** can be formed using a material and a method similar to those of the separation layer **113** disclosed in the above embodiment.
- (193) In this embodiment, the separation layer **2113** is formed of tungsten by a sputtering method.
- (194) <Formation of Base Layer>
- (195) Next, the base layer **2119** is formed over the separation layer **2113** (see FIG. **13**A). In this embodiment, the base layer **2119** is formed of silicon oxide by a plasma CVD method.
- (196) <Formation of Opening>
- (197) Next, part of the base layer **2119** is selectively removed to form the opening **2122***a* (see FIG.
- **13**B). Specifically, a resist mask is formed over the base layer **2119**, and the part of the base layer **2119** is selectively etched with the use of the resist mask. The resist mask can be formed by a
- photolithography method, a printing method, an inkjet method, or the like as appropriate. Formation of the resist mask by an inkjet method needs no photomask; thus, manufacturing costs can be reduced. The base layer **2119** may be etched by either a dry etching method or a wet etching

- method, or by both a dry etching method and a wet etching method. The base layer **2119** is preferably etched under the condition that the etching rate of the base layer **2119** is higher than that of the separation layer **2113**.
- (198) <Oxidation Treatment in Opening>
- (199) Next, a surface of the separation layer **2113** that is exposed because of the formation of the opening **2122***a* is oxidized. The exposed surface of the separation layer **2113** can be oxidized by being in contact with a solution having oxidizability such as a hydrogen peroxide solution or water containing ozone. Alternatively, the exposed surface of the separation layer **2113** can be oxidized by being exposed to an oxygen atmosphere and furthermore being irradiated with ultraviolet light. Further alternatively, the exposed surface of the separation layer **2113** may be exposed to oxygen plasma. In this embodiment, the surface of the separation layer **2113** that is exposed because of the formation of the opening **2122***a* is oxidized by being exposed to oxygen plasma **2126** (see FIG. **13**C).
- (200) Forming an oxide layer on the surface of the separation layer **2113** can facilitate separation of the element formation substrate **2101** performed later.
- (201) <Formation of Terminal Electrode>
- (202) Next, the terminal electrode **2116** overlapping the base layer **2119** and the opening **2122***a* is formed (see FIG. **13**D). The terminal electrode **2116** can be formed using a material and a method similar to those of the terminal electrode **116** disclosed in the above embodiment.
- (203) Note that the separation layer **2113** and the terminal electrode **2116** are in contact with each other in the opening **2122***a* through the surface of the separation layer **2113** that is oxidized by the former oxidation treatment. The oxide layer formed at the interface between the separation layer **2113** and the terminal electrode **2116** can prevent separation of the terminal electrode **2116** with the separation layer **2113** at the time of separation of the element formation substrate **2101** performed later.
- (204) < Formation of Electrode **2115**>
- (205) Next, the electrode **2115** is formed over the base layer **2119**. The electrode **2115** can be formed in a manner similar to that of the terminal electrode **2116**. In this embodiment, the electrode **2115** is formed using a material in which indium tin oxide is stacked over silver. The electrode **2115** and the terminal electrode **2116** are electrically connected to each other (see FIG. **14**A). (206) <Formation of Partition>
- (207) Next, the partition **2114** is formed (see FIG. **14**B). In this embodiment, the partition **2114** is formed in such a manner that a photosensitive organic resin material is applied by a coating method and processed into a desired shape. In this embodiment, the partition **2114** is formed using a photosensitive imide resin.
- (208) < Formation of EL Layer>
- (209) Next, the EL layer **2117** is formed over the electrode **2115** and the partition **2114** (see FIG. **14**C).
- (210) < Formation of Electrode **2118**>
- (211) Next, the electrode **2118** is formed so as to be in contact with the EL layer **2117**. The electrode **2118** can be formed by an evaporation method, a sputtering method, or the like (see FIG. **14**D).
- (212) < Formation of Substrate 2121>
- (213) Next, the substrate **2121** is formed over the electrode **2118** with the bonding layer **2120** provided therebetween (see FIG. **15**A).
- (214) <Separation of Substrate>
- (215) Next, the element formation substrate **2101** and the separation layer **2113** are separated from the base layer **2119** and the terminal electrode **2116** (see FIG. **15**B). The separation can be performed by a method similar to the separation method of the substrate disclosed in the above embodiment.

- (216) < Attachment of Substrate to Light-Emitting Device>
- (217) Next, the substrate **2111** having the opening **2122***b* is attached to the base layer **2119** with the bonding layer **2112** provided therebetween (see FIG. **15**C). At this time, the opening **2122***b* of the substrate **2111** is positioned so that the opening **2122***b* and the opening **2122***a* overlap. The bonding layer **2112** is not formed in a region overlapping the opening **2122***b*. As described above, the opening **2122***a* and the opening **2122***b* are collectively called the opening **2122** in this specification. (218) <Formation of External Electrode>
- (219) Next, the anisotropic conductive connection layer **2123** is formed in the opening **2122**. In addition, the external electrode **2124** for inputting electric power or a signal to the light-emitting device **2100** is formed at the position under the opening **2122**, which the terminal electrode **2116** overlaps (see FIG. **12**). The external electrode **2124** is electrically connected to the terminal electrode **2116** through the anisotropic conductive connection layer **2123**. Thus, electric power a signal can be input to the light-emitting device **2100**. Note that the external electrode **2124** can be formed using a material and a method similar to those of the external electrode **124** disclosed in the above embodiment.
- (220) In one embodiment of the present invention, part of the substrate **2121** does not need to be removed by laser light, with an edged tool, or the like; thus, the display area **2131** and the terminal electrode **2116** are not easily damaged. In addition, the distance between the display area **2131** and the opening **2122** can be shortened; thus, signal attenuation or electrical power attenuation can be suppressed. In addition, the manufacturing process is simplified; thus, the productivity of the light-emitting device can be increased. One embodiment of the present invention can provide a highly reliable light-emitting device having high manufacturing yield. In addition, one embodiment of the present invention can provide a light-emitting device with excellent display quality.

#### Modification Example

- (221) One embodiment of the present invention can be a structure of a light-emitting device **2200** illustrated in FIGS. **16**A and **16**B. FIG. **16**A is a perspective view illustrating an outer appearance of the light-emitting device **2200**, and FIG. **16**B is a cross-sectional view taken along the dashed-dotted line **D1**-**D2** in FIG. **16**A.
- (222) In the light-emitting device **2200**, the shape of the substrate **2111** is different from that in the light-emitting device **2100**. The substrate **2111** included in the light-emitting device **2200** does not have the opening **2122***b*. In addition, the substrate **2111** is attached to the base layer **2119** so that the substrate **2111** and the opening **2122***a* overlap. Thus, the light-emitting device **2200** illustrated in FIGS. **16**A and **16**B has a structure in which edges of the substrate **2121** and the substrate **2111** do not align.
- (223) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (224) In this embodiment, a light-emitting device **2300** having a structure different from the structure of the light-emitting device **2100** described in the above embodiment is described with reference to FIGS. **17**A and **17**B. FIG. **17**A is a perspective view of the light-emitting device **2300**, and FIG. **17**B is a cross-sectional view taken along the dashed-dotted line E**1**-E**2** in FIG. **17**A. (225) <Structure of Light-Emitting Device>
- (226) The light-emitting device **2300** described in this embodiment includes a display area **2231** and a peripheral circuit **2251**. The light-emitting device **2300** also includes a terminal electrode **2216** and the light-emitting element **2125** including the electrode **2115**, the EL layer **2117**, and the electrode **2118**. A plurality of light-emitting elements **2125** are formed in the display area **2231**. A transistor **2232** for controlling the amount of light emitted from the light-emitting element **2125** is connected to each light-emitting element **2125**.
- (227) The terminal electrode **2216** is electrically connected to the external electrode **2124** through the anisotropic conductive connection layer **2123** formed in the opening **2122**. In addition, the

- terminal electrode **2216** is electrically connected to the peripheral circuit **2251**.
- (228) The peripheral circuit **2251** includes a plurality of transistors **2252**. The peripheral circuit **2251** has a function of determining which of the light-emitting elements **2125** in the display area **2231** is supplied with a signal from the external electrode **2124**. Although a structure in which four peripheral circuits **2251** are provided outside the display area **2231** is illustrated in FIG. **17**A, one embodiment of the present invention is not limited to the structure.
- (229) In the light-emitting device **2300** illustrated in FIGS. **17**A and **17**B, the substrate **2111** and the substrate **2121** are attached to each other with the bonding layer **2120** provided therebetween. An insulating layer **2205** is formed over the substrate **2111** with the bonding layer **2112** provided therebetween. The insulating layer **2205** can be formed using a material and a method similar to those of the insulating layer **205** disclosed in the above embodiment.
- (230) Note that the insulating layer **2205** functions as a base layer and can prevent or reduce diffusion of impurity elements from the substrate **2111**, the bonding layer **2112**, or the like to the transistor or the light-emitting element.
- (231) In addition, the transistor **2232**, the transistor **2252**, the terminal electrode **2216**, and a wiring **2219** are formed over the insulating layer **2205**. Note that although a channel-etched transistor that is a type of bottom-gate transistor is illustrated as the transistor **2232** and the transistor **2252** in this embodiment, a channel-protective transistor, a top-gate transistor, or the like can also be used. (232) The transistor **2232** and the transistor **2252** have the same structure. However, the size (e.g., channel length and channel width) or the like of each transistor can be adjusted as appropriate. (233) The transistor **2232** and the transistor **2252** each include a gate electrode **2206**, a gate insulating layer **2207**, a semiconductor layer **2208**, a source electrode **2209***a*, and a drain electrode **2209***b*.
- (234) The terminal electrode **2216**, the wiring **2219**, the gate electrode **2206**, the source electrode **2209***a*, and the drain electrode **2209***b* can be formed using a material and a method similar to those of the terminal electrode **2116**. In addition, the gate insulating layer **2207** can be formed using a material and a method similar to those of the insulating layer **2205**.
- (235) The semiconductor layer **2208** can be formed using a material and a method similar to those of the semiconductor layer **208** disclosed in the above embodiment.
- (236) In the case where an oxide semiconductor is used for the semiconductor layer **2208**, an insulating layer containing oxygen is preferably used as an insulating layer that is in contact with the semiconductor layer **2208**.
- (237) In addition, an insulating layer **2210** is formed over the transistor **2232** and the transistor **2252**, and an insulating layer **2211** is formed over the insulating layer **2210**. The insulating layer **2210** functions as a protective insulating layer and can prevent or reduce diffusion of impurity elements from a layer above the insulating layer **2210** to the transistor **2232** and the transistor **2252**. The insulating layer **2210** can be formed using a material and a method similar to those of the insulating layer **2205**.
- (238) Planarization treatment may be performed on the insulating layer **2211** to reduce unevenness of a surface on which the light-emitting element **2125** is formed. The planarization treatment may be, but not particularly limited to, polishing treatment (e.g., chemical mechanical polishing) or dry etching treatment.
- (239) Forming the insulating layer **2211** using an insulating material with a planarization function can omit polishing treatment. As the insulating material with a planarization function, for example, an organic material such as a polyimide resin or an acrylic resin can be used. Other than the above-described organic materials, it is also possible to use a low-dielectric constant material (low-k material) or the like. Note that the insulating layer **2211** may be formed by stacking a plurality of insulating films formed of these materials.
- (240) In addition, over the insulating layer **2211**, the light-emitting element **2125** and the partition **2114** for separating the adjacent light-emitting elements **2125** are formed.

- (241) In addition, the substrate **2121** is provided with a light-shielding film **2264**, a coloring layer **2266**, and an overcoat layer **2268**. The light-emitting device **2300** is a top-emission light-emitting device, in which light emitted from the light-emitting element **2125** is extracted from the substrate **2121** side through the coloring layer **2266**.
- (242) The light-emitting element **2125** is electrically connected to the transistor **2232** through openings formed in the insulating layer **2211** and the insulating layer **2210**.
- (243) Although an active matrix light-emitting device is described as an example of the light-emitting device in this embodiment, the present invention can also be applied to a passive matrix light-emitting device.
- (244) One embodiment of the present invention can be applied to display devices such as a liquid crystal display device including a liquid crystal element as a display element, an electronic paper, DMD, PDP, FED, and SED, without limitation to a light-emitting device including a light-emitting element as a display element.
- (245) Materials of a liquid crystal element can be similar to those given as examples in the above embodiment. A driving method of a liquid crystal element can be similar to any of the driving methods of the liquid crystal element disclosed in the above embodiment.
- (246) A display method of an electronic paper can be similar to any of the display methods of the electronic paper disclosed in the above embodiment.
- (247) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (248) Structure examples of a light-emitting device **3100** of one embodiment of the present invention are described with reference to FIGS. **18**A to **18**D, FIGS. **19**A to **19**C, and FIGS. **20**A and **20**B. FIG. **18**A is a perspective view illustrating the light-emitting device **3100**, and FIG. **18**B is an enlarged view of a portion **3150** in FIG. **18**A. FIGS. **18**C and **18**D are cross-sectional views taken along the dashed-dotted line F**1**-F**2** in FIG. **18**A. Note that the light-emitting device **3100** disclosed in this specification is a display device in which a light-emitting element is used as a display element.
- (249) < Structure of Light-Emitting Device>
- (250) The light-emitting device **3100** described in this embodiment includes an electrode **3115**, an EL layer **3117**, an electrode **3118**, a partition **3114**, and a terminal electrode **3116**. The electrode **3115** and the terminal electrode **3116** are electrically connected to each other. In the light-emitting device **3100**, the partition **3114** is provided over the electrode **3115**, the EL layer **3117** is provided over the electrode **3118** is provided over the EL layer **3117**.
- (251) A light-emitting element **3125** includes the electrode **3115**, the EL layer **3117**, and the electrode **3118**. The light-emitting element **3125** is formed over a substrate **3111** with a bonding layer **3112** and a base layer **3119** provided therebetween. Note that a plurality of light-emitting elements **3125** are provided in a display area **3131**.
- (252) In addition, in the light-emitting device **3100** described in this embodiment, a substrate **3121** is formed over the electrode **3118** with a bonding layer **3120** provided therebetween.
- (253) The substrate **3121** has a groove **3141**. Although the groove **3141** illustrated in FIGS. **18**A to **18**C penetrate the substrate **3121** in the thickness direction, the groove **3141** does not necessarily penetrate the substrate **3121** in the thickness direction. As illustrated in FIG. **18**D, the groove **3141** may have a given depth without penetrating the substrate **3121**. When the groove **3141** does not penetrate the substrate **3121**, the depth of the groove **3141** is preferably ½ or more, more preferably or more, of the thickness of the substrate **3121**. Note that in a plan view, a region of the substrate **3121** that is surrounded with the groove **3141** is called a portion **3121***a*.
- (254) In addition, a layer **3104** is formed over the terminal electrode **3116**, and a layer **3105** is formed over the layer **3104**. The layer **3104** and the layer **3105** over the terminal electrode **3116** are

formed in a position that the portion **3121***a* overlaps.

sectional view taken along the dashed-dotted line F1-F2 in FIG. 19B.

- (255) As illustrated in FIGS. **19**A to **19**C, the portion **3121***a* and the bonding layer **3120** that the portion **3121***a* overlaps are separated from the light-emitting device **3100**, so that part of the terminal electrode **3116** can be exposed. FIG. **19**A is a perspective view illustrating part of a separation step of the portion **3121***a* and the bonding layer **3120** that the portion **3121***a* overlaps. FIG. **19**B is a perspective view illustrating a state after the separation step. FIG. **19**C is a cross-
- (256) The portion **3121***a* and the bonding layer **3120** that the portion **3121***a* overlaps are removed to form an opening **3122**, so that part of the terminal electrode **3116** can be exposed.
- (257) Providing the layer **3104** and the layer **3105** in positions that the portion **3121***a* overlaps facilitates separation of the portion **3121***a* with the bonding layer **3120** that the portion **3121***a* overlaps, so that the terminal electrode **3116** can be exposed. Note that the layer **3104** and the layer **3105** are described in detail later.
- (258) As illustrated in FIGS. **20**A and **20**B, an external electrode **3124** and the terminal electrode **3116** can be electrically connected to each other through an anisotropic conductive connection layer **3123** in the opening **3122**. Thus, a region of the substrate **3121** that overlaps the opening **3122** is also called an external electrode connection region. FIG. **20**A is a perspective view of the lightemitting device **3100** to which the external electrode **3124** is connected, and FIG. **20**B is a cross-sectional view taken along the dashed-dotted line F1-F2 in FIG. **20**A.
- (259) A switching element for controlling a signal supplied to the light-emitting element **3125** may be provided between the light-emitting element **3125** and the terminal electrode **3116**. For example, a transistor may be provided between the light-emitting element **3125** and the terminal electrode **3116**.
- (260) A transistor is a kind of semiconductor element and enables amplification of current or voltage, switching operation for controlling conduction or non-conduction, or the like. By providing a transistor between the light-emitting element **3125** and the terminal electrode **3116**, the area of the display area **3131** can be increased easily and a higher-resolution display can be achieved easily. Note that a resistor, an inductor, a capacitor, or the like, without limitation to a switching element such as a transistor, can be provided in the display area **3131**.
- (261) <Substrates>
- (262) The substrate **3111** and the substrate **3121** can be formed using materials similar to those of the substrate **121** and the substrate **111** disclosed in the above embodiment. In the case where the light-emitting device **3100** is a bottom-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer **3117** is used for the substrate **3111**. In the case where the light-emitting device **3100** is a top-emission light-emitting device or a dual-emission light-emitting device, a material that transmits light emitted from the EL layer **3117** is used for the substrate **3121**.
- (263) <Base Layer>
- (264) The base layer **3119** can be formed using a material and a method similar to those of the base layer **119** disclosed in the above embodiment.
- (265) The base layer **3119** can prevent or reduce diffusion of impurity elements from the substrate **3111**, the bonding layer **3112**, or the like to the light-emitting element **3125**.
- (266) <Terminal Electrode>
- (267) The terminal electrode **3116** can be formed using a material and a method similar to those of the terminal electrode **116** disclosed in the above embodiment.
- (268) <Electrode **3115**>
- (269) The electrode **3115** is preferably formed using a conductive material that efficiently reflects light emitted from the EL layer **3117** formed later. The electrode **3115** can be formed using a material and a method similar to those of the electrode **115** disclosed in the above embodiment. (270) The light-emitting device having a top emission structure is described as an example in this

embodiment. In the case of a light-emitting device having a bottom emission structure or a dual emission structure, the electrode **3115** may be formed using a light-transmitting conductive material.

- (271) < Partition>
- (272) The partition **3114** is provided in order to prevent an electrical short circuit between the adjacent electrodes **3118**. In the case of using a metal mask for formation of the EL layer **3117** described later, the partition **3114** also has a function of preventing the metal mask from being in contact with a region where the light-emitting element **3125** is formed. The partition **3114** can be formed using a material and a method similar to those of the partition **114** disclosed in the above embodiment. The partition **3114** is preferably formed so that its sidewall has a tapered shape or a tilted surface with a continuous curvature. The sidewall of the partition **3114** having the above-described shape enables favorable coverage with the EL layer **3117** and the electrode **3118** formed later.
- (273) <EL Layer>
- (274) A structure of the EL layer **3117** is described in Embodiment 9.
- (275) <Electrode **3118**>
- (276) The electrode **3118** is used as a cathode in this embodiment, and thus is preferably formed using a material that has a low work function and can inject electrons into the EL layer **3117** described later. The electrode **3118** can be formed using a material and a method similar to those of the electrode **118** disclosed in the above embodiment.
- (277) In the case where light emitted from the EL layer **3117** is extracted through the electrode **3118**, the electrode **3118** preferably has a property of transmitting visible light.
- (278) <Bonding Layer>
- (279) The bonding layer **3120** is in contact with the electrode **3118** in this embodiment. The substrate **3121** is fixed by the bonding layer **3120**. In addition, the substrate **3111** is fixed by the bonding layer **3112**. The bonding layer **3120** and the bonding layer **3112** can be formed using a material and a method similar to those of the bonding layer **120** and the bonding layer **112** disclosed in the above embodiment. A drying agent (e.g., zeolite) having a size less than or equal to the wavelength of light or a filler (e.g., titanium oxide or zirconium) with a high refractive index is preferably mixed into the bonding layer **3120** in the case of a top emission structure or into the bonding layer **3112** in the case of a bottom emission structure, in which case the efficiency of extracting light emitted from the EL layer **3117** can be improved.
- (280) < Anisotropic Conductive Connection Layer>
- (281) The anisotropic conductive connection layer **3123** can be formed using a material and a method similar to those of the anisotropic conductive connection layer **123** disclosed in the above embodiment.
- (282) < Method for Manufacturing Light-Emitting Device>
- (283) Next, an example of a method for manufacturing the light-emitting device **3100** is described with reference to FIGS. **21**A to **21**E, FIGS. **22**A and **22**B, FIGS. **23**A and **23**B, and FIGS. **24**A to **24**C. FIGS. **21**A to **24**C are cross-sectional views taken along the dashed-dotted line F**1**-F**2** in FIGS. **18**A and **18**B, FIGS. **19**A and **19**B, and FIG. **20**A.
- (284) < Formation of Separation Layer>
- (285) First, the separation layer **3113** is formed over an element formation substrate **3101** (see FIG.
- **21**A). Note that the element formation substrate **3101** can be formed using a material similar to that of the element formation substrate **101** disclosed in the above embodiment.
- (286) The separation layer **3113** can be formed using a material and a method similar to those of the separation layer **113** disclosed in the above embodiment.
- (287) In this embodiment, the separation layer **3113** is formed of tungsten by a sputtering method.
- (288) < Formation of Base Layer>
- (289) Next, the base layer 3119 is formed over the separation layer 3113 (see FIG. 21A). In this

- embodiment, the base layer **3119** is formed of silicon oxide by a plasma CVD method. (290) <Formation of Terminal Electrode>
- (291) Next, the terminal electrode **3116** is formed over the base layer **3119**. First, a three-layer metal film in which aluminum is interposed between two layers of molybdenum is formed over the base layer **3119** by a sputtering method. After that, a resist mask is formed over the metal film, and the metal film is etched into a desired shape with the use of the resist mask. In the above-described manner, the terminal electrode **3116** can be formed. The resist mask can be formed by a photolithography method, a printing method, an inkjet method, or the like as appropriate. Formation of the resist mask by an inkjet method needs no photomask; thus, manufacturing costs can be reduced.
- (292) The metal film may be etched by either a dry etching method or a wet etching method, or by both a dry etching method and a wet etching method. In the case where the metal film is etched by a wet etching method, a solution obtained by mixing phosphoric acid, acetic acid, and nitric acid, a solution containing oxalic acid, a solution containing phosphoric acid, or the like can be used as an etchant. After the etching treatment, the resist mask is removed (see FIG. **21**B).
- (293) < Formation of Electrode >
- (294) Next, the electrode **3115** is formed over the base layer **3119**. The electrode **3115** can be formed in a manner similar to that of the terminal electrode **3116**. In this embodiment, the electrode **3115** is formed using a material in which indium tin oxide is stacked over silver. The electrode **3115** and the terminal electrode **3116** are electrically connected to each other (see FIG. **21**B). (295) <Formation of Partition>
- (296) Next, the partition **3114** is formed (see FIG. **21**C). In this embodiment, the partition **3114** is formed in such a manner that a photosensitive organic resin material is applied by a coating method and processed into a desired shape. In this embodiment, the partition **3114** is formed using a photosensitive imide resin.
- (297) <Formation of EL Layer>
- (298) Next, the EL layer **3117** is formed over the electrode **3115** and the partition **3114**. At the same time as the EL layer **3117**, the layer **3104** is formed in a region on the terminal electrode **3116** that the opening **3122** is to overlap (see FIG. **21**D). The layer **3104** can be formed using a material and a method similar to those of the EL layer **3117**.
- (299) <Formation of Electrode>
- (300) Next, the electrode **3118** is formed in contact with the EL layer **3117**. At the same time as the electrode **3118**, the layer **3105** is formed in a region on the layer **3104** that the opening **3122** is to overlap. The layer **3105** can be formed using part of a layer formed at the same time as the electrode **3118**. The electrode **3118** and the layer **3105** can be formed by an evaporation method, a sputtering method, or the like (see FIG. **21**E).
- (301) < Formation of Substrate >
- (302) Next, the substrate **3121** having the groove **3141** penetrating the substrate **3121** in the thickness direction is formed over the electrode **3118** with the bonding layer **3120** provided therebetween. At this time, the substrate **3121** is formed so that the portion **3121***a* of the substrate **3121** overlaps the terminal electrode **3116**, the layer **3104**, and the layer **3105** (see FIG. **22**A). (303) Note that the layer **3104** is formed to have a size with which the outer edges of the layer **3104** are located outside the portion **3121***a* when seen from the top. In addition, the layer **3105** is formed to have a size with which the outer edges of the layer **3105** are located inside the portion **3121***a* when seen from the top.
- (304) Note that in the case where the groove **3141** has a given depth, the groove **3141** may be formed in such a manner that the substrate **3121** without the groove **3141** is formed over the electrode **3118** first and then the groove **3141** is formed in the substrate **3121** with a sharp edged tool or by laser light.
- (305) If a sharp edged tool or laser light penetrates the substrate 3121 at this time, the terminal

- electrode **3116** or another portion might be damaged. For this reason, it is necessary that the groove **3141** does not penetrate the substrate **3121** in the case where the groove **3141** is formed after the substrate **3121** is formed over the electrode **3118**.
- (306) Meanwhile, in the case where the formed groove **3141** is shallow, it is difficult to separate the portion **3121***a* in a later step. When the groove **3141** does not penetrate the substrate **3121**, the depth of the groove **3141** is preferably ½ or more, more preferably ½ or more, of the thickness of the substrate **3121**.
- (307) <Separation of Substrate>
- (308) Next, the element formation substrate **3101** and the separation layer **3113** are separated from the base layer **3119** (see FIG. **22**B). The separation can be performed by a method similar to the separation method of the substrate disclosed in the above embodiment.
- (309) < Attachment of Substrate to Light-Emitting Device>
- (310) Next, the substrate **3111** is attached to the base layer **3119** with the bonding layer **3112** provided therebetween (see FIG. **23**A). In the above-described manner, the light-emitting device **3100** can be manufactured (see FIG. **23**B).
- (311) Next, steps for electrically connecting the terminal electrode **3116** and the external electrode **3124** are described.
- (312) < Exposure of Surface of Terminal Electrode>
- (313) An adhesive tape is attached onto the portion **3121***a* of the substrate **3121**, and then the adhesive tape is pulled upward to be removed, so that the portion **3121***a* is separated from the substrate **3121** along the groove **3141**. At this time, the bonding layer **3120** and the layer **3105** that the portion **3121***a* overlaps can be removed together with the portion **3121***a* because of low adhesion between the layer **3104** and the layer **3105** (see FIG. **19**A and FIG. **24**A).
- (314) Note that the layer **3105** is not necessarily formed. However, the layer **3105** is formed at the interface between the bonding layer **3120** and the layer **3104**, whereby the bonding layer **3120** that the portion **3121***a* overlaps hardly remains on the light-emitting device **3100** side at the time of the separation of the portion **3121***a*. Thus, by forming the layer **3105** at the interface between the bonding layer **3120** and the layer **3104**, manufacturing yield can be improved.
- (315) < Removal of Layer **3104**>
- (316) Next, the layer **3104** is removed with an organic solvent such as ethyl alcohol to expose part of a surface of the terminal electrode **3116** (see FIG. **19**B and FIG. **24**B).
- (317) < Formation of External Electrode>
- (318) Next, the anisotropic conductive connection layer 3123 is formed in the opening 3122, and the external electrode 3124 for inputting electric power or a signal to the light-emitting device 3100 is formed over the anisotropic conductive connection layer 3123 (see FIG. 24C). The external electrode 3124 and the terminal electrode 3116 are electrically connected to each other through the anisotropic conductive connection layer 3123. Thus, electric power or a signal can be input to the light-emitting device 3100. Note that the external electrode 3124 can be formed using a material and a method similar to those of the external electrode 124 disclosed in the above embodiment. (319) In one embodiment of the present invention, the groove 3141 is formed in the substrate 3121, and the layer 3104 and the layer 3105 are formed at the interface between the bonding layer 3120 and the terminal electrode 3116, so that the terminal electrode 3116 can be exposed easily. Thus, there is no need to hollow out part of the substrate 3121 with a sharp edged tool or the like for exposure of the terminal electrode 3116; thus, the light-emitting device 3100 and the terminal electrode 3116 are not easily damaged.
- (320) The layer **3104** can be formed in the same step as the EL layer **3117**. The layer **3105** can be formed in the same step as the electrode **3118**. Thus, the portion **3121***a* can be removed easily without increasing the number of manufacturing steps of the light-emitting device **3100**. One embodiment of the present invention can provide a highly reliable light-emitting device having high manufacturing yield.

- (321) The portion **3121***a* has a function of protecting the terminal electrode **3116**. The light-emitting device **3100** is stored and transferred without separating the portion **3121***a*, whereby the terminal electrode **3116** can be protected when stored and transferred, and breakage of the light-emitting device **3100** due to electrostatic electricity or the like can be prevented.
- (322) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (323) FIGS. **25**A to **25**E and FIGS. **26**A to **26**E are each an enlarged plan view of a region of the substrate **3121** that overlaps the terminal electrode **3116**. FIGS. **25**A to **25**E and FIGS. **26**A to **26**E illustrate arrangement examples of the grooves **3141**.
- (324) In the plan view, a portion surrounded with the grooves **3141** is the portion **3121***a*. In other words, the grooves **3141** are formed along the outer edge of the portion **3121***a*. In the case where the grooves **3141** penetrate the substrate **3121** in the thickness direction, it is necessary to prevent a reduction in manufacturing yield due to unintentional separation of the portion **3121***a* from the substrate **3121** before attachment of the substrate **3121** onto the substrate **3111**. For this reason, it is necessary to form at least two regions without grooves **3141** along the outer edge of the portion **3121***a* (the region is hereinafter called "gap a").
- (325) FIGS. **25**A to **25**E and FIG. **26**A each illustrate an example in which the grooves **3141** are formed in the form of perforations along the outer edge of the rectangular portion **3121***a* in the plan view. Note that the perforations are continuously formed holes for facilitating separation and the groove **3141** corresponds to the hole.
- (326) In the case where the groove **3141** does not penetrate the substrate **3121** in the thickness direction, unintentional separation of the portion **3121***a* can be prevented even if the grooves **3141** are not formed in the form of perforations. Thus, in the case where the groove **3141** does not penetrate the substrate **3121** in the thickness direction, the outer edge of the portion **3121***a* can be surrounded with one groove **3141**. Note that the grooves **3141** that do not penetrate the substrate **3121** in the thickness direction may be formed in the form of perforations.
- (327) In FIG. **25**A, the groove **3141** is not formed in both ends of each short side of the portion **3121***a*, and the long side formed of the groove **3141** and the short side formed of the groove **3141** are separated by the gap a.
- (328) FIG. **25**B illustrates a modification example of the structure illustrated in FIG. **25**A, in which the long sides of the portion **3121***a* are each formed of two grooves **3141**.
- (329) Note that the length of the gap a is the shortest distance between an end of the groove **3141** and an end of the adjacent groove **3141**. In the case where a plurality of grooves **3141** are formed in the form of perforations, a too large gap a makes the separation of the portion **3121***a* difficult. The length of the gap a is preferably 50 times or less, more preferably 20 times or less, still more preferably 10 times or less of the thickness of the substrate **3121**. In addition, the longer the length b of one groove **3141** is, the easier the separation of the portion **3121***a* is. The length b of one groove **3141** is preferably longer than or equal to the length of the gap a.
- (330) FIG. **25**C illustrates another modification example of the structure illustrated in FIG. **25**A, in which each long side of the portion **3121***a* is formed of eight grooves **3141**.
- (331) FIG. **25**D illustrates an example in which the grooves **3141** along the outer edge of the portion **3121***a* that are separated in the middle of the four sides of the portion **3121***a* are provided. In FIG. **25**D, the portion **3121***a* with a rectangular shape is made up of four L-shaped grooves **3141**.
- (332) FIG. **25**E illustrates an example in which the grooves **3141** are formed along the outer edge of the portion **3121***a* and the gap a is provided in part of each of the two short sides of the portion **3121***a*. In FIG. **25**E, the portion **3121***a* is made up of two L-shaped grooves **3141**.
- (333) FIG. **26**A illustrates an example in which one long side and one short side of the portion **3121***a* are formed of the L-shaped groove **3141** and the other long side and short side of the portion

- **3121***a* are formed of the grooves **3141** in the form of perforations.
- (334) FIG. **26**B illustrates an example in which the short sides of the portion **3121***a* are formed of dogleg grooves **3141**.
- (335) FIG. **26**C is a modification example in which the two parallel grooves **3141** in FIG. **26**B are formed of each a plurality of grooves **3141**.
- (336) FIG. **26**D is another modification example in which the dogleg grooves **3141** in FIG. **26**B are arc-shaped grooves **3141**.
- (337) Ends of the portion **3121***a* are extended outward in the plan view as illustrated in FIGS. **26**B to **26**D, whereby the portion **3121***a* can be separated more easily.
- (338) The grooves **3141** may be formed across the substrate **3121** as illustrated in FIG. **26**E. However, ends of the portion **3121***a* are easily in contact with storage equipment, a jig, or the like at the time of storage or transfer of the light-emitting device **3100**, which might cause unintentional separation or partial separation of the portion **3121***a*. In addition, when the portion **3121***a* is separated to expose the terminal electrode **3116**, the mechanical strength of the region, i.e., the external electrode connection region is significantly decreased; thus, the external electrode connection region is easily deformed unintentionally, which easily causes breakage or the like of the light-emitting device **3100**.
- (339) Meanwhile, the portion **3121***a* is formed inside edges of the substrate **3121** in a plan view, so that the outer edge of the external electrode connection portion can be supported by the substrate **3111** and the substrate **3121**. This can make it difficult to increase the mechanical strength of the external electrode connection region and can reduce unintentional deformation of the external electrode connection region. Thus, breakage of the light-emitting device **3100** can be prevented, and the reliability of the light-emitting device **3100** can be improved.
- (340) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (341) In this embodiment, a light-emitting device **3200** having a structure different from the structure of the light-emitting device **3100** described in the above embodiment is described with reference to FIGS. **27**A and **27**B. FIG. **27**A is a top view of the light-emitting device **3200**, and FIG. **27**B is a cross-sectional view of a portion taken along the dashed-dotted line G**1**-G**2** in FIG. **27**A.
- (342) <Structure of Light-Emitting Device>
- (343) The light-emitting device **3200** described in this embodiment includes a display area **3231** and a peripheral circuit **3251**. The light-emitting device **3200** also includes a terminal electrode **3216** and the light-emitting element **3125** including the electrode **3115**, the EL layer **3117**, and the electrode **3118**. A plurality of light-emitting elements **3125** are formed in the display area **3231**. A transistor **3232** for controlling the amount of light emitted from the light-emitting element **3125** is connected to each light-emitting element **3125**.
- (344) The terminal electrode **3216** is electrically connected to the external electrode **3124** through the anisotropic conductive connection layer **3123** formed in the opening **3122**. In addition, the terminal electrode **3216** is electrically connected to the peripheral circuit **3251**.
- (345) The peripheral circuit **3251** includes a plurality of transistors **3252**. The peripheral circuit **3251** has a function of determining which of the light-emitting elements **3125** in the display area **3231** is supplied with a signal from the external electrode **3124**.
- (346) In the light-emitting device **3200** illustrated in FIGS. **27**A and **27**B, the substrate **3111** and the substrate **3121** are attached to each other with the bonding layer **3120** provided therebetween. An insulating layer **3205** is formed over the substrate **3111** with the bonding layer **3112** provided therebetween. The insulating layer **3205** can be formed using a material and a method similar to those of the insulating layer **205** disclosed in the above embodiment.
- (347) Note that the insulating layer **3205** functions as a base layer and can prevent or reduce

- diffusion of impurity elements from the substrate **3111**, the bonding layer **3112**, or the like to the transistor or the light-emitting element.
- (348) In addition, the transistor **3232**, the transistor **3252**, the terminal electrode **3216**, and a wiring **3219** are formed over the insulating layer **3205**. Note that although a channel-etched transistor that is a type of bottom-gate transistor is illustrated as the transistor **3232** and the transistor **3252** in this embodiment, a channel-protective transistor, a top-gate transistor, or the like can also be used. It is also possible to use a dual-gate transistor, in which a semiconductor layer in which a channel is formed is interposed between two gate electrodes.
- (349) The transistor **3232** and the transistor **3252** may have the same structure. However, the size (e.g., channel length and channel width) or the like of each transistor can be adjusted as appropriate.
- (350) The transistor **3232** and the transistor **3252** each include a gate electrode **3206**, a gate insulating layer **3207**, a semiconductor layer **3208**, a source electrode **3209***a*, and a drain electrode **3209***b*.
- (351) The terminal electrode **3216**, the wiring **3219**, the gate electrode **3206**, the source electrode **3209***a*, and the drain electrode **3209***b* can be formed using a material and a method similar to those of the terminal electrode **3116**. In addition, the gate insulating layer **3207** can be formed using a material and a method similar to those of the insulating layer **3205**.
- (352) The semiconductor layer **3208** can be formed using a material and a method similar to those of the semiconductor layer **208** disclosed in the above embodiment.
- (353) In the case where an oxide semiconductor is used for the semiconductor layer **3208**, an insulating layer containing oxygen is preferably used as an insulating layer that is in contact with the semiconductor layer **3208**.
- (354) In addition, an insulating layer **3210** is formed over the transistor **3232** and the transistor **3252**, and an insulating layer **3211** is formed over the insulating layer **3210**. The insulating layer **3210** functions as a protective insulating layer and can prevent or reduce diffusion of impurity elements from a layer above the insulating layer **3210** to the transistor **3232** and the transistor **3252**. The insulating layer **3210** can be formed using a material and a method similar to those of the insulating layer **3205**.
- (355) Planarization treatment may be performed on the insulating layer **3211** to reduce unevenness of a surface on which the light-emitting element **3125** is formed. The planarization treatment may be, but not particularly limited to, polishing treatment (e.g., chemical mechanical polishing) or dry etching treatment.
- (356) Forming the insulating layer **3211** using an insulating material with a planarization function can omit polishing treatment. As the insulating material with a planarization function, for example, an organic material such as a polyimide resin or an acrylic resin can be used. Other than the above-described organic materials, it is also possible to use a low-dielectric constant material (low-k material) or the like. Note that the insulating layer **3211** may be formed by stacking a plurality of insulating films formed of these materials.
- (357) In addition, over the insulating layer **3211**, the light-emitting element **3125** and the partition **3114** for separating the adjacent light-emitting elements **3125** are formed.
- (358) In addition, the substrate **3121** is provided with a light-shielding film **3264**, a coloring layer **3266**, and an overcoat layer **3268**. The light-emitting device **3200** is what is called a top-emission light-emitting device in which light emitted from the light-emitting element **3125** is extracted from the substrate **3121** side through the coloring layer **3266**.
- (359) The light-emitting element **3125** is electrically connected to the transistor **3232** through the opening formed in the insulating layer **3211** and the insulating layer **3210**.
- (360) Although an active matrix light-emitting device is described as an example of the light-emitting device in this embodiment, the present invention can also be applied to a passive matrix light-emitting device.

- (361) One embodiment of the present invention can be applied to display devices such as a liquid crystal display device including a liquid crystal element as a display element, an electronic paper, DMD, PDP, FED, and SED, without limitation to a light-emitting device including a light-emitting element as a display element.
- (362) An example of a liquid crystal element can be similar the liquid crystal element disclosed in the above embodiment. A driving method of a liquid crystal element can be similar to any of the driving methods of the liquid crystal element disclosed in the above embodiment.
- (363) A display method of an electronic paper can be similar to any of the display methods of the electronic paper disclosed in the above embodiment.
- (364) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (365) In this embodiment, structure examples of a light-emitting element that can be applied to the light-emitting element **125**, the light-emitting element **2125**, and the light-emitting element **3125** are described. Note that an EL layer **320** described in this embodiment corresponds to the EL layer **117**, the EL layer **2117**, and the EL layer **3117** described in the above embodiments.
- (366) <Structure of Light-Emitting Element>
- (367) In a light-emitting element **330** illustrated in FIG. **28**A, the EL layer **320** is interposed between a pair of electrodes (a first electrode **318** and a second electrode **322**). Note that the first electrode **318** is used as an anode and the second electrode **322** is used as a cathode as an example in the following description of this embodiment.
- (368) The EL layer **320** includes at least a light-emitting layer and may have a stacked-layer structure including a functional layer other than the light-emitting layer. As the functional layer other than the light-emitting layer, a layer containing a substance having a high hole-injection property, a substance having a high hole-transport property, a substance having a high electron-injection property, a bipolar substance (a substance having high electron- and hole-transport properties), or the like can be used. Specifically, functional layers such as a hole-injection layer, a hole-transport layer, an electron-transport layer, and an electron-injection layer can be used in combination as appropriate.
- (369) The light-emitting element **330** illustrated in FIG. **28**A emits light when current flows because of a potential difference generated between the first electrode **318** and the second electrode **322** and holes and electrons are recombined in the EL layer **320**. That is, the light-emitting region is formed in the EL layer **320**.
- (370) In the present invention, light emitted from the light-emitting element **330** is extracted to the outside from the first electrode **318** side or the second electrode **322** side. Therefore, one of the first electrode **318** and the second electrode **322** is formed of a light-transmitting substance.
- (371) Note that a plurality of EL layers **320** may be stacked between the first electrode **318** and the second electrode **322** as in a light-emitting element **331** illustrated in FIG. **28**B. In the case where n (n is a natural number of 2 or more) layers are stacked, a charge generation layer **320***a* is preferably provided between an m-th EL layer **320** and an (m+1)-th EL layer **320**. Note that m is a natural number greater than or equal to 1 and less than n.
- (372) The charge generation layer **320***a* can be formed using a composite material of an organic compound and a metal oxide, a metal oxide, a composite material of an organic compound and an alkali metal, an alkaline earth metal, or a compound thereof; alternatively, these materials can be combined as appropriate. Examples of the composite material of an organic compound and a metal oxide include composite materials of an organic compound and a metal oxide such as vanadium oxide, molybdenum oxide, and tungsten oxide. As the organic compound, a variety of compounds can be used; for example, low molecular compounds such as an aromatic amine compound, a carbazole derivative, and aromatic hydrocarbon and high molecular compounds (e.g., oligomer, dendrimer, and polymer). As the organic compound, it is preferable to use the organic compound

which has a hole-transport property and has a hole mobility of 10.sup.—6 cm.sup.2/Vs or higher. However, substances other than the substances given above may also be used as long as the substances have higher hole-transport properties than electron-transport properties. These materials used for the charge generation layer **320***a* have excellent carrier-injection properties and carrier-transport properties; thus, the light-emitting element **330** can be driven with low current and with low voltage.

- (373) Note that the charge generation layer **320***a* may be formed with a combination of a composite material of an organic compound and a metal oxide and another material. For example, a layer containing a composite material of the organic compound and the metal oxide may be combined with a layer containing a compound of a substance selected from substances with an electron-donating property and a compound with a high electron-transport property. Moreover, a layer containing a composite material of the organic compound and the metal oxide may be combined with a transparent conductive film.
- (374) The light-emitting element **331** having such a structure is unlikely to have problems such as energy transfer and quenching and has an expanded choice of materials, and thus can easily have both high emission efficiency and a long lifetime. Moreover, it is easy to obtain phosphorescence from one EL layer and fluorescence from the other EL layer.
- (375) The charge generation layer **320***a* has a function of injecting holes to one of the EL layers **320** that is in contact with the charge generation layer **320***a* and a function of injecting electrons to the other EL layer **320** that is in contact with the charge generation layer **320***a*, when voltage is applied to the first electrode **318** and the second electrode **322**.
- (376) The light-emitting element **331** illustrated in FIG. **28**B can provide a variety of emission colors by changing the type of the light-emitting substance used for the EL layer **320**. In addition, a plurality of light-emitting substances emitting light of different colors may be used as the light-emitting substances, whereby light emission having a broad spectrum or white light emission can be obtained.
- (377) In the case of obtaining white light emission using the light-emitting element **331** illustrated in FIG. **28**B, as for the combination of a plurality of EL layers, a structure for emitting white light including red light, green light, and blue light may be used; for example, the structure may include a first light-emitting layer containing a blue fluorescent substance as a light-emitting substance and a second light-emitting layer containing red and green phosphorescent substances as light-emitting substances. Alternatively, a structure including a first light-emitting layer emitting red light, a second light-emitting layer emitting green light, and a third light-emitting layer emitting blue light may be employed. Further alternatively, with a structure including light-emitting layers emitting light of complementary colors, white light emission can be obtained. When light emitted from the first light-emitting layer and light emitted from the second light-emitting layer have complementary colors to each other in a stacked-layer element including two light-emitting layers, the combinations of colors are as follows: blue and yellow, blue-green and red, and the like. (378) Note that in the structure of the above-described stacked-layer element, by providing the charge generation layer between the stacked light-emitting layers, the element can have a long lifetime in a high-luminance region while keeping the current density low. In addition, the voltage drop due to the resistance of the electrode material can be reduced, whereby uniform light emission in a large area is possible.
- (379) This embodiment can be implemented in an appropriate combination with any of the structures described in the other embodiments.

- (380) In this embodiment, examples of an electronic appliance and a lighting device including the light-emitting device of one embodiment of the present invention are described with reference to drawings.
- (381) As examples of electronic appliances with flexibility, the following can be given: television

- devices (also called televisions or television receivers), monitors of computers or the like, digital cameras, digital video cameras, digital photo frames, mobile phones (also called cellular phones or mobile phone devices), portable game machines, portable information terminals, audio reproducing devices, large game machines such as pachinko machines, and the like.
- (382) In addition, a lighting device or a display device can be incorporated along a curved inside/outside wall surface of a house or a building or a curved interior/exterior surface of a car.
- (383) FIG. **29**A illustrates an example of a mobile phone. A mobile phone **7400** is provided with a display portion **7402** incorporated in a housing **7401**, an operation button **7403**, an external connection port **7404**, a speaker **7405**, a microphone **7406**, and the like. Note that the mobile phone **7400** is manufactured using the light-emitting device in the display portion **7402**.
- (384) When the display portion **7402** of the mobile phone **7400** illustrated in FIG. **29**A is touched with a finger or the like, data can be input to the mobile phone **7400**. Further, operations such as making a call and inputting a character can be performed by touch on the display portion **7402** with a finger or the like.
- (385) The power can be turned on or off with the operation button **7403**. In addition, types of images displayed on the display portion **7402** can be switched; for example, switching images from a mail creation screen to a main menu screen.
- (386) Here, the display portion **7402** includes the light-emitting device of one embodiment of the present invention. Thus, the mobile phone can have a curved display portion and high reliability. (387) FIG. **29**B is an example of a wristband-type display device. A portable display device **7100** includes a housing **7101**, a display portion **7102**, an operation button **7103**, and a sending and receiving device **7104**.
- (388) The portable display device **7100** can receive a video signal with the sending and receiving device **7104** and can display the received video on the display portion **7102**. In addition, with the sending and receiving device **7104**, the portable display device **7100** can send an audio signal to another receiving device.
- (389) With the operation button **7103**, power ON/OFF, switching displayed videos, adjusting volume, and the like can be performed.
- (390) Here, the display portion **7102** includes the light-emitting device of one embodiment of the present invention. Thus, the portable display device can have a curved display portion and high reliability.
- (391) FIGS. **29**C to **29**E illustrate examples of lighting devices. A lighting device **7200**, a light-emitting device **7210**, and a light-emitting device **7220** each include a stage **7201** provided with an operation switch **7203** and a light-emitting portion supported by the stage **7201**.
- (392) The lighting device **7200** illustrated in FIG. **29**C includes a light-emitting portion **7202** with a wave-shaped light-emitting surface and thus is a good-design lighting device.
- (393) A light-emitting portion **7212** included in the lighting device **7210** illustrated in FIG. **29**D has two convex-curved light-emitting portions symmetrically placed. Thus, light radiates from the lighting device **7210**.
- (394) The lighting device **7220** illustrated in FIG. **29**E includes a concave-curved light-emitting portion **7222**. This is suitable for illuminating a specific range because light emitted from the light-emitting portion **7222** is collected to the front of the lighting device **7220**.
- (395) The light-emitting portion included in each of the lighting devices **7200**, **7210**, and **7220** are flexible; thus, the light-emitting portion may be fixed on a plastic member, a movable frame, or the like so that an emission surface of the light-emitting portion can be bent freely depending on the intended use.
- (396) The light-emitting portions included in the lighting devices **7200**, **7210**, and **7220** each include the light-emitting device of one embodiment of the present invention. Thus, the lighting devices can have curved light-emitting portions and high reliability.
- (397) FIG. **30**A illustrates an example of a portable display device. A display device **7300** includes

- a housing **7301**, a display portion **7302**, operation buttons **7303**, a display portion pull **7304**, and a control portion **7305**.
- (398) The display device **7300** includes a rolled flexible display portion **7102** in the cylindrical housing **7301**.
- (399) The display device **7300** can receive a video signal with the control portion **7305** and can display the received video on the display portion **7302**. In addition, a battery is included in the control portion **7305**. Moreover, a connector may be included in the control portion **7305** so that a video signal or power can be supplied directly.
- (400) With the operation buttons **7303**, power ON/OFF, switching of displayed videos, and the like can be performed.
- (401) FIG. **30**B illustrates a state in which the display portion **7302** is pulled out with the display portion pull **7304**. Videos can be displayed on the display portion **7302** in this state. Further, the operation buttons **7303** on the surface of the housing **7301** allow one-handed operation.
- (402) Note that a reinforcement frame may be provided for an edge portion of the display portion **7302** in order to prevent the display portion **7302** from being curved when pulled out.
- (403) Note that in addition to this structure, a speaker may be provided for the housing so that sound is output with an audio signal received together with a video signal.
- (404) The display portion **7302** includes the light-emitting device of one embodiment of the present invention. Thus, the display portion **7302** is a flexible, highly reliable display portion, which makes the display device **7300** lightweight and highly reliable.
- (405) It is needless to say that one embodiment of the present invention is not limited to the above-described electronic appliances and lighting devices as long as the light-emitting device of one embodiment of the present invention is included.
- (406) This embodiment can be combined with any of the other embodiments disclosed in this specification as appropriate.
- (407) This application is based on Japanese Patent Application serial no. 2013-051231 filed with the Japan Patent Office on Mar. 14, 2013, Japanese Patent Application serial no. 2013-093328 filed with the Japan Patent Office on Apr. 26, 2013, and Japanese Patent Application serial no. 2013-120369 filed with the Japan Patent Office on Jun. 7, 2013, the entire contents of which are hereby incorporated by reference.

#### **Claims**

- 1. Alight-emitting device comprising: a first bonding layer over a first substrate; a terminal electrode and a first electrode over the first bonding layer; a partition over the first electrode; an EL layer over the first electrode and the partition; a second electrode over the EL layer; a second bonding layer over the second electrode; a second substrate over the second bonding layer; and a conductive layer over the second substrate, wherein the conductive layer is electrically connected to the terminal electrode through an opening in the second bonding layer and the second substrate.
- 2. The light-emitting device according to claim 1, wherein each of the first substrate and the second substrate is a flexible substrate.
- 3. The light-emitting device according to claim 1, wherein the conductive layer is an anisotropic conductive connection layer.
- 4. The light-emitting device according to claim 1, further comprising an external electrode electrically connected to the conductive layer.
- 5. Alight-emitting device comprising: a first bonding layer over a first substrate; a terminal electrode and a first electrode over the first bonding layer; a partition over the first electrode; an EL layer over the first electrode and the partition; a second electrode over the EL layer; a second bonding layer over the second electrode; a second substrate over the second bonding layer; and a conductive layer over the second substrate, wherein the conductive layer is electrically connected

to the terminal electrode through an opening in the second bonding layer and the second substrate, and wherein the partition covers a portion where the first electrode is in contact with the terminal electrode.

- 6. The light-emitting device according to claim 5, wherein each of the first substrate and the second substrate is a flexible substrate.
- 7. The light-emitting device according to claim 5, wherein the conductive layer is an anisotropic conductive connection layer.
- 8. The light-emitting device according to claim 5, further comprising an external electrode electrically connected to the conductive layer.